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### Antenna device and camera system

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#### Abstract

An antenna device includes an antenna array in which a plurality of antennas each including a negative differential resistance element and a resonance circuit are arranged, a voltage bias circuit which applies a voltage to the antenna array, a first shunt element which is connected between the antenna array and the voltage bias circuit in parallel relation to each of the negative differential resistance element and the voltage bias circuit, and in which a first resistor and a first capacitor of the first shunt element are connected in series, and a second shunt element which is connected between the first shunt element and the voltage bias circuit in parallel relation to each of the negative differential resistance element and the voltage bias circuit, and in which a second resistor and a second capacitor of the second shunt element are connected in series.

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## Background/Summary

CROSS-REFERENCE TO RELATED APPLICATIONS (1) This application is a Continuation of International Patent Application No. PCT/JP2021/047654, filed on Dec. 22, 2021, which claims the benefit of Japanese Patent Applications No. 2021-015981, filed on Feb. 3, 2021 and Japanese Patent Application No. 2021-199839, filed on Dec. 9, 2021, which are hereby incorporated by reference herein in their entirety.

## BACKGROUND OF THE INVENTION

### Field of the Invention

(1) The present disclosure relates to an antenna device that transmits or receives an electromagnetic wave and to a camera system.

### Description of the Related Art

(2) An antenna including a negative differential resistance element and a resonance circuit can generate an electromagnetic wave (hereinafter referred to simply as the “terahertz wave”) including at least a part of a frequency band from a millimeter wave to a terahertz wave (at least 30 GHz and not more than 30 THz). By way of example, PTL 1 discloses an antenna having a negative differential resistance element and a resonance circuit each integrated in a semiconductor chip to generate the terahertz wave.

(3) In PTL 1, as the negative differential resistance element, a resonant tunneling diode (RTD) is used, and a power source that supplies a bias voltage to the negative differential resistance element is included. The bias voltage from the power source is supplied to the negative resistance element via a bias supply unit including wiring and a conductor. Parasitic low-frequency oscillation (parasitic oscillation) other than the terahertz wave generated from an antenna is often generated by a structure accompanying the bias supply unit. Therefore, PTL 1 discloses a technology of placing a shunt element in the bias supply unit and thereby suppressing the parasitic oscillation.

## CITATION LIST

### Patent Literature

(4) PTL 1 Japanese Patent Application Publication No. 2015-180049

(5) As a means for enhancing an antenna output, there is an approach in which a plurality of antennas each including a negative differential resistance element and a resonance circuit are

arranged to provide an antenna array. In a case of mounting a chip integrated with this antenna array on another substrate such as a ceramic package or a printed substrate, the chip and the substrate are connected using bonding wires, and a shunt element for suppressing the parasitic oscillation is placed on the substrate.

(6) Each of the bonding wires and a resistor and a capacitor each included in the shunt element has a parasitic inductance. The parasitic inductance cannot be ignored in terms of normally generating the terahertz wave, and causes the parasitic oscillation at a frequency (less than 30 GHz) lower than that of the terahertz wave. Due to the parasitic inductance, the parasitic oscillation particularly at 10 MHz to 10 GHz is likely to occur. In such an antenna array, to normally oscillate the terahertz wave, it is necessary to optimize circuit parameters and the placement of the shunt element on the substrate but, in PTL 1, sufficient examination has not been conducted.

(7) It is therefore an object of the present disclosure is to provide a technology of suppressing parasitic oscillation in an antenna device having an antenna array including negative differential resistance elements and resonance circuits.

## SUMMARY OF THE INVENTION

(8) For the above object, an antenna device of the present disclosure includes an antenna device transmitting or receiving an electromagnetic wave, the antenna device including an antenna array in which a plurality of antennas each including a negative differential resistance element and a resonance circuit are arranged, a voltage bias circuit which applies a voltage to the antenna array, a first shunt element which is connected between the antenna array and the voltage bias circuit in parallel relation to each of the negative differential resistance element and the voltage bias circuit, and in which a first resistor and a first capacitor of the first shunt element are connected in series, and a second shunt element which is connected between the first shunt element and the voltage bias circuit in parallel relation to each of the negative differential resistance element and the voltage bias circuit, and in which a second resistor and a second capacitor of the second shunt element are connected in series, wherein each of the first shunt element and the second shunt element has a low impedance with respect to a resistance value of the negative differential resistance element used as a reference.

(9) In addition, an antenna of the present disclosure includes an antenna device transmitting or receiving an electromagnetic wave, the antenna device including a chip having an antenna array in which a plurality of antennas each including a negative differential resistance element and a resonance circuit are arranged, a substrate on which the chip is to be placed, and a voltage bias circuit that applies a voltage to the antenna array, wherein the chip has a first shunt element connected in parallel to each of the negative differential resistance element and the voltage bias circuit and including at least a first capacitor, and a plurality of pads including at least each of a first pad and a second pad to supply a predetermined voltage to the antenna array, the substrate has a second shunt element connected in parallel to each of the negative differential resistance element and the voltage bias circuit, and including at least a second capacitor, and moreover placed in the substrate, and wherein the antenna array is located between the first pad and the second pad.

Further, a camera system of the present disclosure includes a camera system including the antenna device as described above, a detection device for detecting the electromagnetic wave transmitted from the antenna device, and a processing unit that processes a signal from the detection device.

(10) Further features of the present invention will become apparent from the following description of exemplary embodiments with reference to the attached drawings.

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## Description

### BRIEF DESCRIPTION OF THE DRAWINGS

(1) FIG. 1 illustrates an example of a plan view of an antenna device according to a first

embodiment.

(2) FIG. 2 illustrates an example of a cross-sectional view of the antenna device according to the first embodiment.

(3) FIG. 3 illustrates an example of the cross-sectional view of the antenna device according to the first embodiment.

(4) FIGS. 4A and 4B are illustrative views illustrating an antenna array according to the first embodiment.

(5) FIG. 5 is an equivalent circuit diagram of the antenna device according to the first embodiment.

(6) FIG. 6 illustrates a graph illustrating the antenna device according to the first embodiment.

(7) FIG. 7 illustrates a graph illustrating the antenna device according to the first embodiment.

(8) FIG. 8 illustrates a diagram illustrating the antenna device according to the first embodiment.

(9) FIGS. 9A and 9B illustrate diagrams illustrating the antenna device according to the first embodiment.

(10) FIG. 10 illustrates an example of a plan view of an antenna device according to a second embodiment.

(11) FIG. 11 illustrates an example of a plan view of an antenna device according to a third embodiment.

(12) FIG. 12 illustrates an example of a plan view of an antenna device according to a fourth embodiment.

(13) FIG. 13 illustrates an example of the plan view of the antenna device according to the fourth embodiment.

(14) FIG. 14 illustrates an example of the plan view of the antenna device according to the fourth embodiment.

(15) FIG. 15 illustrates an example of a plan view of an antenna device according to a fifth embodiment.

(16) FIG. 16 illustrates an example of the plan view of the antenna device according to the fifth embodiment.

(17) FIG. 17 illustrates an equivalent circuit diagram of an antenna device according to a sixth embodiment.

(18) FIG. 18 is an illustrative view illustrating an antenna array according to the sixth embodiment.

(19) FIG. 19 illustrates an example of a cross-sectional view of the antenna device according to the sixth embodiment.

(20) FIG. 20 is an illustrative view illustrating an antenna array according to a modification of the sixth embodiment.

(21) FIG. 21 illustrates an example of a cross-sectional view of an antenna device according to the modification of the sixth embodiment.

(22) FIG. 22 illustrates an example of the plan view of the antenna device according to the fourth embodiment.

(23) FIG. 23 illustrates a schematic diagram for illustrating a camera system according to a seventh embodiment.

## DESCRIPTION OF THE EMBODIMENTS

(24) Using the drawings, a description will be given below of embodiments of the present disclosure. Note that the present disclosure is not limited to the following embodiments, and can appropriately be modified within a scope not departing from the gist thereof. In addition, in the drawings described below, components having the same functions are denoted by the same reference signs, and a description thereof may be omitted or simplified.

### First Embodiment

(25) Using FIGS. 1 to 9, a description will be given of an antenna device according to the first embodiment. FIG. 1 is a plan view illustrating a schematic configuration of the antenna device according to the present embodiment. FIG. 2 is a cross-sectional view along a line A-A' in FIG. 1.

(26) As illustrated in FIGS. 1 and 2, in an antenna device **100** according to the present embodiment, a chip **11** having a quadrilateral shape on which an antenna array **12** including a plurality of antennas **121** are arranged is mounted on a substrate **10**. FIG. 1 illustrates a configuration on a top surface of the chip **11**. Each of the antennas **121** includes a negative differential resistance element and a resonance circuit, and transmits or receives an electromagnetic wave in a terahertz frequency band, though details of the antenna **121** will be described later. The antenna **121** generates an electromagnetic wave (hereinafter referred to simply as a “terahertz wave”) including a frequency band corresponding to at least a part of a frequency band (at least 30 GHz and not more than 30 THz) from a millimeter wave to the terahertz wave. In addition, the adjacent antennas **121** are configured to be capacitively coupled via a microstrip line (described later using FIG. 4).

(27) The chip **11** includes, in addition to the antenna array **12**, a resistance element **131** and a capacitance element **132** each included in a first shunt element **1300**, a pad **141** that applies a bias voltage to the chip **11**, and a pad **142** that applies a ground voltage to the chip **11**. The pads **141** and **142** are for achieving an electrical connection to a circuit outside the chip **11** and for, e.g., supplying a predetermined voltage from the outside. The pads **141** and **142** are made of a conductor. Hereinbelow, the pads are for electrical connection to the outside. Specifically, the pads may be for a supply of a predetermined voltage from the outside and for a supply of the predetermined voltage to the outside. In the present embodiment, the predetermined voltage may be the ground voltage, a power source voltage, a voltage from a voltage bias circuit, or the like.

(28) The antenna array **12** is placed substantially at a center of the chip **11**, and the capacitance element **132** is placed adjacent to the antenna array **12**. Such placement of the capacitance element **132** as to surround the antenna array **12** can also enlarge an area of the capacitance element placed on the chip **11** and ensure a large capacitance. The capacitance element **132** is also divided to be arranged on respective sides (a right side and a left side of the chip **11** in the figure) with two facing sides of the chip **11** such that the antenna array **12** is interposed therebetween. This allows the resistance element **131**, wiring, the pads, and the like to be placed in a portion (upper side of the chip **11** in the figure) where the capacitance element **132** is not placed, and can thereby reduce a chip size of the chip **11**.

(29) As illustrated in FIG. 2, one terminal of the resistance element **131** is connected to one terminal of the capacitance element **132** via each of wiring **133** and a via **134**. The resistance element **131** and the capacitance element **132** are connected in series and, for easy placement of the connection, the resistance element **131** is preferably placed in the vicinity of the capacitance element **132**. Alternatively, the resistance element **131** may also be placed on the capacitance element **132** in overlapping relation thereto. Another terminal of the resistance element **131** is connected to the pad **141** via a bias voltage line **130**. The bias voltage line **130** is placed between the individual antennas **121** in the antenna array **12** to be connected commonly to the individual antennas **121** and apply the bias voltage to each of the antennas **121**. Another terminal of the capacitance element **132** is connected to the pad **142** via wiring and a via (not shown).

(30) As the capacitance element **132**, a MIM (Metal-Insulator-Metal) capacitor in which an insulating layer is interposed between metal layers can be used. As the metal layers, wiring layers in the chip **11** can be used while, as the insulating layer, an insulating layer and a dielectric layer each forming the antennas can be used. According to the present embodiment, as illustrated in FIG. 2, as one electrode of the MIM capacitor, a grounded metal layer **124** is used, and the grounded metal layer **124** is connected to the pad **142** that applies the ground voltage. As another electrode of the MIM capacitor, a metal layer **139** is formed via the insulating layer. The metal layer **139** is connected to the wiring **133** via the via **134**. By thus configuring the MIM capacitor, it is possible to form the capacitor in the chip by a simple and convenient manufacturing process.

(31) In addition to the configuration described above, a configuration in which a capacitor is formed on a substrate other than that of the chip **11** to be bonded to the top surface or a back surface of the chip **11** is also possible, and this configuration allows a larger-capacitance

capacitance element to be included.

(32) In the first shunt element **1300**, the resistance element **131** is connected to the pad **141** that applies the bias voltage, while the capacitance element **132** is connected to the pad **142** that applies the ground voltage. However, it may also be possible to invert a connection relationship and connect the resistance element **131** to the pad **142** that applies the ground voltage, while connecting the capacitance element **132** to the pad **141** that applies the bias voltage.

(33) Preferably, on the chip **11**, as the antennas **121** in the antenna array **12**, 20 to 40 antennas are arranged. In addition, the number of the pads **141** for the application of the bias voltage and the number of the pads **142** that apply the ground voltage are set smaller than the number of the antennas. This allows a space of the chip **11** to be effectively used and allows a further size reduction of the chip **11**. Moreover, when the number of pairs of the resistance elements **131** and the capacitance elements **132** is not more than the number of the pads **141** for the application of the bias voltage or not more than the number of the pads **142** that apply the ground voltage, it is possible to effectively use the space of the chip **11** and allow a further size reduction of the chip **11**.

(34) The substrate **10** includes a resistance element **151** and a capacitance element **152** each included in a second shunt element **1500**, a pad **161** to be connected to the pad **141** of the chip **11**, and a pad **162** to be connected to the pad **142** of the chip **11**. The pads **161** and **162** are for achieving electric connection to an external circuit outside the chip **11**. The pads **161** and **162** are made of a conductor. The external circuit mentioned herein is the chip **11**. The substrate **10** also includes a connection terminal **181** to which the bias voltage is to be supplied from the voltage bias circuit **17** and a connection terminal **182** that gives the ground voltage. For a size reduction of the substrate **10**, it is preferable to use a surface mount component (SMD: Surface Mount Device) as the resistance element **151** or the capacitance element **152**. Since wiring to be placed in the substrate **10** also has a resistance value, as the resistance element **151**, a resistance of wiring in the substrate **10** included in a path connecting the first shunt element **1300** and the second shunt element **1500** may also be used. This can reduce the number of components used in the chip **11** and achieve a size reduction of the chip **11**. The connection terminals **181** and **182** may also be pads herein.

(35) The voltage bias circuit **17** is connected from the outside of the substrate **10** via the connection terminals **181** and **182**. Note that, instead of using this configuration, it may also be possible to place the voltage bias circuit **17** in the substrate **10** or in the chip **11**.

(36) The pad **141** of the chip **11** and the pad **161** of the substrate **10** are connected with a bonding wire **191**. The pad **142** of the chip **11** and the pad **162** of the substrate **10** are connected with a bonding wire **192**. To reduce inductances of the bonding wires **191** and **192**, it is preferable to arrange the pad **141** and the pad **161** as well as the pad **142** and the pad **162** close to each other and reduce lengths of the bonding wires **191** and **192**.

(37) To shorten the bonding wires **191** and **192**, the pad **141** and the pad **142** are arranged appropriately on an end portion of the chip **11**. Meanwhile, the pad **141** and the pad **161** are arranged appropriately to face each other with the side of the chip **11** being interposed therebetween. In addition, the pad **142** and the pad **162** are also arranged appropriately to face each other with the side of the chip **11** being interposed therebetween.

(38) One terminal **1512** of the resistance element **151** is connected to one terminal **1521** of the capacitance element **152** via wiring **157**. In other words, the resistance element **151** and the capacitance element **152** are connected in series. Accordingly, the resistance element **151** and the capacitance element **152** are preferably arranged adjacent to each other. More preferably, the one terminal **1512** of the resistance element **151** is placed adjacent to the one terminal **1521** of the capacitance element **152**. This can reduce a length of the wiring **157** and reduce the inductance.

(39) Another terminal **1511** of the resistance element **151** is connected to the pad **161** via wiring **153** and also connected to the connection terminal **181** via wiring **154**. Another terminal **1522** of the capacitance element **152** is connected to the pad **162** via wiring **155** and also connected to the

connection terminal **182** via wiring **156**. It is preferable that a direction in which the terminals **1511** and **1512** of the resistance element **151** and the terminals **1521** and **1522** of the capacitance element **152** are arranged is set the same as a direction in which the pad **161** and the pad **162** are arranged. Such an arrangement can shorten the wiring to be connected and reduce the inductance.

(40) In the second shunt element **1500**, the resistance element **151** is connected to the connection terminal **181** to which the bias voltage is to be applied, while the capacitance element **132** is connected to the connection terminal **182** that applies the ground voltage. However, it may also be possible to invert a connection relationship and connect the resistance element **131** to the connection terminal **182** that applies the ground voltage and connect the capacitance element **132** to the connection terminal **181** to which the bias voltage is to be applied.

(41) In the present embodiment, an example is assumed in which the first shunt element **1300** and the second shunt element **1500** respectively include the resistance elements **131** and **151** and the capacitance elements **132** and **152**. However, each of the first shunt element and the second shunt element may also be configured to include either one of the resistance element and the capacitance element. In a case where the shunt element includes the capacitance element, it becomes possible not only to suppress capacitive oscillation, but also reduce power consumption by using a frequency characteristic of the impedance to cut a dc current.

(42) Positional relationships among the components of the antenna device **100** are such that, between the antenna array **12** and the voltage bias circuit **17**, the first shunt element **1300** is placed and, between the first shunt element **1300** and the voltage bias circuit **17**, the second shunt element **1500** is placed.

(43) FIG. **3** is a partial cross-sectional view of the antenna device **100** illustrating a configuration in which the pad is formed on the back surface of the chip **11** to connect the chip **11** and the substrate **10** without using bonding wires **19**. According to FIG. **3**, the wiring present in the top surface of the chip **11** is connected to the pad **141** present on the back surface of the chip **11** via the through electrode **135**.

(44) The through electrode **135** is formed by forming a through hole in the chip **11**, subsequently forming an insulating film for electrical isolation on an inner wall of the through hole, and filling the through hole with copper or the like, which has a low electric resistance and can easily form an electrode by an electrolytic plating method or the like. The through electrode **135** is smoothed using CMP (Chemical Mechanical Polishing) processing or the like. After the through electrode **135** is formed, the pad **141** is formed on the back surface of the chip **11** so as to be electrically connected to the through electrode **135**.

(45) The pad **141** on the back surface of the chip **11** and the pad **161** on the substrate **10** are arranged so as to overlap each other and connected by soldering or the like. In a case of providing the electrical connection using the through electrode **135**, no bonding wire is used, and accordingly the inductance is reduced to easily suppress the parasitic oscillation in the antenna device **100**.

(46) FIG. **4** are illustrative views illustrating the antenna array **12** in the present embodiment. FIG. **4A** is a top view of the antenna array **12**, while FIG. **4B** is a cross-sectional view of the antenna array **12** along a line B-B' in FIG. **4A**. In the figures, by way of example, the two antennas **121** and **122** included in the antenna array **12** are illustrated.

(47) Normally, in an antenna array intended for power synthesis, each of intervals between individual antennas is set to a wavelength converted to a wavelength of an oscillating electromagnetic wave in vacuum or less, to an integral multiple of the wavelength, or more preferably to a half-wavelength or less. In the present embodiment, the antennas **121** and **122** are arranged such that the interval between the antennas is not more than a half-wavelength of a transmitted electromagnetic wave.

(48) In the antenna array **12**, a resonance circuit **1200** is configured to control an oscillation frequency by using a microstrip resonator including a metal layer **123** corresponding to a first conductor forming a part of each of the antennas, a dielectric layer **128**, and the grounded metal



layer **124** corresponding to a second conductor forming a part of each of the antennas. Each of the antennas **121** and **122** includes the resonance circuit **1200** and a negative differential resistance element **127**. To the metal layer **123**, the bias voltage line **130** is connected via the via **134**, and the bias voltage is applied to the negative differential resistance element **127**. The negative differential resistance element **127** generates an electromagnetic wave gain for maintaining oscillation. The individual antennas **121** and **122**, which are synchronized in the same phase to oscillate, are designed such that a frequency close to an oscillation frequency  $\omega_0$  is reached. Accordingly, the individual antennas including half-wavelength resonators preferably have respective shapes similar to each other. The negative differential resistance elements **127** also preferably have respective shapes and characteristics equal to each other. A microstrip line **125** is an inter-element structure for causing individual antennas as described above to be synchronized in the same phase to oscillate.

(49) The microstrip line **125** which is a transmission line of a metal portion serving as an ink structure has a length from one end to another end along the microstrip line **125** which is preferably chosen to be a in terms of an electric length at the oscillation frequency  $\omega_0$  after the synchronization. The electric length of a is a length corresponding to an effective oscillation wavelength  $\lambda_{\text{sub}0}$  converted in terms of an effective dielectric constant in a surrounding structure. As the electric length, a is chosen so as to synchronize the antennas **121** and **122** in the same phase and oscillate the antennas **121** and **122**. In a case of synchronizing the antennas **121** and **122** in opposite phases, the electric length may also be  $\pi$  or  $3\pi$ . Even when the length of the microstrip line **125** is not precisely  $2\pi$ , the synchronization of the antennas **121** and **122** is possible. Although depending on a magnitude of coupling between elements formed via the microstrip line **125**, an electric length of about  $2\pi \pm 10\%$  is typically in an allowable range. Note that the allowable range is wider than when coupling is provided without using the microstrip line **125**. Note that the electric length of the microstrip line can easily be checked with an electromagnetic field simulator or the like.

(50) A part of an oscillation output of the antenna **121** is input in substantially the same phase to the adjacent antenna **122** via the microstrip line **125**. Meanwhile, a part of an oscillation output of the antenna **122** is input in substantially the same phase to the adjacent antenna **121** via the microstrip line **125**. In the antenna array in the present embodiment, to implement such a mutual injection locking phenomenon between the antennas **121** and **122**, the microstrip line **125** has been introduced.

(51) The microstrip line **125** in the present embodiment is characterized by capacitive coupling with the metal layer **123** of a resonance structure. The microstrip line **125** and the metal layer **123** only form a capacitor via the insulating layer **129** in a metal-insulator-metal (MIM) region **126**, and are in a DC-open-state. Accordingly, in a band of the oscillation frequency  $\omega_0$ , antenna-to-antenna coupling of a magnitude as large as that of direct coupling can be ensured. In addition, in a low frequency region lower than  $\omega_0$ , the magnitude of the coupling decreases, and therefore it is possible to ensure isolation between the antennas. The microstrip line **125** in the present embodiment having such a property is preferable. Additionally, in the frequency region lower than  $\omega_0$ , the microstrip line **125** having open end portions serves as a capacitive element. When viewed from the negative differential resistance element **127** on an antenna **121** side, the microstrip line **125** is the capacitive element, and the metal layer **123** of the resonance structure on an antenna **122** side is also a capacitor. As a result, in the low frequency region, there is no generation of resonance frequencies of concern. Therefore, it is possible to suppress the parasitic oscillation in the low frequency region.

(52) With reference to FIGS. 4A and 4B, the description has been given of the two individual antennas **121** and **122** and, in the antenna array **12**, the individual antennas can be arrayed by being arranged in the same configuration as that of the antennas **121** and **122**. In addition, on the grounded metal layer **124**, the plurality of metal layers **123** corresponding to the number of the arrays are placed via the dielectric layer **128**, and the negative differential resistance elements **127**

corresponding to the metal layers **123** are placed. The adjacent antennas are capacitively coupled via the microstrip lines **125**. Each of the microstrip lines **125** has an electric length of about  $2\pi$ . Accordingly, it becomes possible to synchronize all the negative differential resistance elements **127** in the same phase. As a result of thus arraying the antennas, not only synthesized electric power is increased, but also a sharp directionality is favorably obtained.

(53) Note that, inside the chip **11**, the plurality of metal layers **123** are connected commonly via a strip conductor (not shown) to be connected to the pad **141** to which the bias voltage is to be applied, while the grounded metal layer **124** is connected to the pad **142** inside the chip **11**. With this configuration, when the voltage is applied to each of the pad **141** and the pad **142**, the bias voltage is applied to the negative differential resistance elements **127**.

(54) As each of the negative differential resistance elements **127**, a resonant tunneling diode that is lattice-matched to an InP substrate can be used. Note that the negative differential resistance element **127** is not limited to the resonant tunneling diode, and an Esaki diode or a Gunn diode may also be used. The resonance tunnelling diode is configured to include, e.g., a multiple quantum well structure including InGaAs/InAlAs and InGaAs/AlAs on the InP substrate and an electric contact layer including n-InGaAs. As the multiple quantum well structure, e.g., a triple-barrier structure is used. More specifically, the multiple quantum well structure is formed of a semiconductor multilayer film structure including AlAs (1.3 nm)/InGaAs (7.6 nm)/InAlAs (2.6 nm)/InGaAs (5.6 nm)/AlAs (1.3 nm). Among these layers, InGaAs is a well layer, while lattice-matched InAlAs and non-matched AlAs are barrier layers. These layers are intentionally left undoped by not performing carrier doping. Such a multiple quantum well structure is interposed between the electric contact layers including n-InGaAs at an electron density of  $2 \times 10^{18} \text{ cm}^{-3}$ . A current-voltage (UV) characteristic of such a structure between the electric contact layers has a peak current density of  $280 \text{ kA/cm}^2$ , and a negative resistance region ranges from about 0.7 V to about 0.9 V. As a configuration of the diode, in a case of a mesa structure having a diameter of  $2 \mu\text{m}$ , a peak current value of 10 mA and a negative resistance value of  $-20\Omega$  are obtained. When consideration is given to a reactance resulting from a junction capacitance of the resonant tunneling diode having a diameter of  $2 \mu\text{m}$  and connected to a lower part of the metal layer **123**, an oscillation frequency is about 0.55 THz.

(55) Next, FIG. 5 illustrates an equivalent circuit diagram of the antenna device according to the present embodiment. An equivalent circuit of the chip **11** has a resistance  $r$  of each of the negative differential resistance elements included in the antenna array **12** ( $r$  represents an absolute value of a resistance of the negative differential resistance element). The equivalent circuit of the chip **11** also has an impedance  $Z$  of the resonance circuit **1200** included in the antenna array **12** and a resistance  $R_c$  of the resistance element **131** included in the first shunt element **1300**. The equivalent circuit of the chip **11** further has a capacitance  $C_c$  of the capacitance element **132** included in the first shunt element **1300**.

(56) The first shunt element **1300** is configured to include the resistance  $R_c$  and the capacitance  $C_c$  which are connected in series. In addition, the resistance  $r$ , the impedance  $Z$  of the resonance circuit **1200**, and the first shunt element **1300** are connected in parallel to each other. More specifically, one terminal of the resistance  $r$ , one terminal of the impedance  $Z$  of the resonance circuit **1200**, and one terminal of the resistance  $R_c$  are each connected to a first node  $n1$ . Meanwhile, another terminal of the resistance  $R_c$  is connected to one terminal of the capacitance  $C_c$ . In addition, another terminal of the resistance  $r$ , another terminal of the impedance  $Z$  of the resonance circuit **1200**, and another terminal of the capacitance  $C_c$  are connected to the ground voltage. The first node  $n1$  is connected to the pad **141** of the chip **11**, and the ground voltage is applied via the pad **142** of the chip **11**.

(57) An equivalent circuit of the substrate **10** is configured to include a resistance  $R_p$  of the resistance element **151** included in the second shunt element **1500**, a capacitance  $C_p$  of the capacitance element **152** included therein, and an inductance  $L$  of the path connecting the first

shunt element **1300** and the second shunt element **1500**. The inductance L includes respective parasitic inductances of the wiring connecting the first shunt element **1300** and the pad **141**, the bonding wires connecting the chip and the substrate, and the wiring, the pads, and the like connecting the bonding wires and the second shunt element **1500**.

(58) The second shunt element **1500** is configured to include the resistance  $R_p$  and the capacitance  $C_p$  which are connected in series. In addition, the chip **11** and the second shunt element **1500** are connected via the inductance L. More specifically, one terminal of the inductance L is connected to the first node  $n_1$  in the equivalent circuit of the chip **11**, and another terminal of the inductance L and one terminal of the resistance  $R_p$  are connected to a second node  $n_2$ . Meanwhile, another terminal of the resistance  $R_p$  is connected to one terminal of the capacitance  $C_p$ . To another terminal of the capacitance  $C_p$ , the ground voltage is applied. The second node  $n_2$  is further connected to the terminal **181**, and a voltage bias circuit V is connected thereto. Consequently, to the second node  $n_2$ , the bias voltage is applied and, to the resistance  $r$ , the bias voltage is applied via the inductance L.

(59) The first shunt element **1300** (the resistance  $R_c$  and the capacitance  $C_c$ ) is connected in parallel to the negative differential resistance element (the resistance  $r$ ), and is also connected in parallel to the second shunt element **1500** (the resistance  $R_p$  and the capacitance  $C_p$ ) via the inductance L. Furthermore, the first shunt element **1300** is also connected in parallel to the voltage bias circuit V.

(60) In such an antenna device, to suppress the parasitic oscillation, each of the first shunt element **1300** and the second shunt element **1500** has a low impedance with respect to the resistance  $r$  of the negative differential resistance element **127** used as a reference. In other words, in a frequency band lower than the terahertz frequency band, each of the first shunt element **1300** and the second shunt element **1500** is preferably set to have a low impedance when viewed from the negative differential resistance element **127**. In this case, a conditional expression including Expressions (1) and (2) below is satisfied:

$$R_p + 1/(2\pi \times f \times C_p) < r \quad (1)$$

$$R_c + 1/(2\pi \times f \times C_c) < r \quad (2)$$

where  $r$  is an absolute value of a resistance value of the negative differential resistance element,  $R_c$  is a resistance value of the resistance  $R_c$  corresponding to a first resistor, and  $C_c$  is a capacitance value of the capacitance  $C_c$  corresponding to a first capacitor. Also,  $R_p$  is a resistance value of the resistance  $R_p$  corresponding to a second resistor,  $C_p$  is a capacitance value of the capacitance  $C_p$  corresponding to a second capacitor, and L is the inductance of the path connecting the first shunt element **1300** and the second shunt element **1500**. Also,  $f$  represents a frequency of the targeted parasitic oscillation, which is a frequency less than a resonance frequency of each of the resonance circuits included in the antenna array **12**. The frequency  $f$  is specifically less than 30 GHz, and is particularly a frequency in a range of 10 MHz to 10 GHz in a case where the chip **11** is mounted on the substrate **10** used in the present embodiment.

(61) However, even when Expressions (1) and (2) are satisfied, LC resonance in the inductance L and the capacitance  $C_c$  may possibly occur. To suppress the LC resonance, it is necessary to ensure  $R_c$  in order to cause an oscillation energy loss, and it is preferable to reduce L and increase  $C_c$ . Therefore, to suppress the capacitive oscillation, a conditional expression including Expression (3) below is also satisfied:

$$L/(C_c \times r) < R_c \quad (3)$$

(62) FIG. 6 is a graph representing a frequency characteristic of the impedance when viewed from the negative differential resistance element **127** when a value of the inductance L is varied on the basis of the equivalent circuit in FIG. 5. A broken line represents a characteristic with respect to  $L=1$  nH, a solid line represents a characteristic with respect to 5 nH, a dash-dot line represents a characteristic with respect to 10 nH, and the impedance has a peak value at a specified frequency. Specifically, with respect to  $L=1$  nH, a peak value is  $1.8\Omega$  at 160 MHz, with respect to  $L=5$  nH, a

peak value is  $16.8\Omega$  at 50 MHz, and, with respect to  $L=10$  nH, a peak value is  $8.5\Omega$  at 71 MHz.

(63) FIG. 7 is a graph representing a relationship between the inductance  $L$  and the peak value of the inductance when viewed from the negative differential resistance element **127** on the basis of the frequency characteristic in FIG. 6. According to FIG. 7, as the inductance  $L$  increases, the peak value of the impedance increases.

(64) At the frequency  $f$  of the capacitive oscillation to be suppressed, when the impedance of a line when viewed from the negative differential resistance element **127** is not more than 10 times the absolute value of the negative differential resistance, a magnitude of a loss due to the line with respect to a gain of the negative differential resistance element **127** can no longer be ignored. Thus, it is possible to suppress oscillation of the LC resonance. By way of example, in an antenna array having a chip size of 3 mm square to 4 mm square, 20 to 40 antennas can be arranged, and a combined resistance value of the negative differential resistance elements **127** is  $1\Omega$  at most, i.e., not more than  $1\Omega$ . Accordingly, as long as a resistance value is not more than  $10\Omega$  which is ten times this resistance value, the parasitic oscillation can be suppressed. In other words, according to the graph in FIG. 7,  $L \leq 5$  nH needs only to be satisfied.

(65) The inductance  $L$  includes the respective parasitic inductances of the wiring connecting the first shunt element **1300** and the pad **141**, the bonding wires connecting the chip and the substrate, and the wiring, the pads, and the like connecting the bonding wires and the second shunt element **1500**. Each of these inductances of the path connecting the first shunt element **1300** and the second shunt element **1500** can be calculated using Expressions (4) and (5) below. Of the path connecting the first shunt element **1300** and the second shunt element **1500**, a portion having a cross section that can be approximated to a substantially circular shape is calculated using Expression (4), while a portion thereof having a cross section that can be approximated to a quadrilateral shape is calculated using Expression (5).

$$L1 = 0.2 \times l1 \times [\ln(4 \times l1 / d) - 0.75] \text{ [nH]} \quad (4)$$

$$L2 = 0.2 \times l2 \times [\ln\{2 \times l2 / (w + h)\} + 0.2235] \times (w + h) / l2 + 0.5 \text{ [nH]} \quad (5)$$

where  $l1$  is a length (mm) of the portion of the path having the cross section that can be approximated to the substantially circular shape, and  $d$  is a diameter (mm) of a cross section thereof. Also,  $l2$  is a length (mm) of the portion of the path having the cross section that can be approximated to the quadrilateral shape,  $w$  is a width (mm) thereof, and  $h$  is a thickness (mm) thereof.

(66) FIG. 8 is a diagram illustrating the inductance of the path connecting the first shunt element **1300** and the second shunt element **1500** in the present embodiment. The path connecting the first shunt element **1300** and the second shunt element **1500** has wiring (first portion P1) connecting the resistance element **131** included in the first shunt element **1300** and the pad **141** as well as the pad **141** (second portion P2). The path further has the bonding wire **19** (third portion P3), the pad **161** (fourth portion P4), and wiring (fifth portion P5) connecting the pad **161** and the resistance element **151** included in the second shunt element **1500**.

(67) A length of the path connecting the first shunt element **1300** and the second shunt element **1500** is preferably not more than 4 mm, which is appropriate to reduce the parasitic inductance and suppress the parasitic oscillation. More preferably, the length of the path is not more than 2 mm.

(68) A description will be given below of dimensions of each of the portions of the path as well as an example of the inductance calculated using Expression (4) or Expression (5).

(69) The first portion P1 has a length of 0.3 mm, a width of 0.2 mm, and a thickness of 0.5  $\mu\text{m}$ , and an inductance  $L1$  of this region is calculated using Expression (5) to be 0.1 nH.

(70) An inductance  $L2$  of the second portion P2 is calculated on the assumption that the second portion P2 is a region from an end portion of the pad **141** to substantially a center portion of the pad **141** to which the bonding wire **19** is connected. This region has a length of 0.1 mm, a width of 0.2 mm, and a thickness of 0.5  $\mu\text{m}$ , and the inductance  $L2$  of this region is calculated using Expression (5) to be 0.02 nH.

(71) The third portion P3 is the bonding wire having a length of 1.0 mm and a cross section diameter of 20  $\mu\text{m}$ , and an inductance L3 of this region is calculated using Expression (4) to be 0.91 nH.

(72) An inductance L4 of the fourth portion P4 is calculated on the assumption that the fourth portion P4 is a region from an end portion of the pad 161 to substantially a center portion of the pad 161 to which the bonding wire 19 is connected. This region has a length of 0.6 mm, a width of 1.2 mm, and a thickness of 35  $\mu\text{m}$ , and the inductance L4 is calculated using Expression (5) to be 0.11 nH.

(73) The fifth portion P5 has a length of 0.8 mm, a width of 0.6 mm, and a thickness of 35  $\mu\text{m}$ , and an inductance L5 of this region is calculated using Expression (5) to be 0.26 nH.

(74) Accordingly, the inductance of the path connecting the first shunt element 1300 and the second shunt element 1500 can be calculated as a total of the inductances L1, L2, L3, L4, and L5 to be 1.4 nH.

(75) In the present embodiment, the inductance is calculated using Expression (4) on the assumption that the bonding wire 19 has a circular cross section, but it may also be possible to use a ribbon-shaped bonding wire having a quadrilateral cross section. In a case of the ribbon-shaped bonding wire, the inductance can be calculated using Expression (5). The ribbon-shaped bonding wire can have a large cross-sectional area, and the inductance can be reduced.

(76) FIGS. 9A and 9B are diagrams illustrating the calculation of the inductance of the wiring. A description will be given herein by using the wiring 153 connecting the pad 161 and the resistance element 151 included in the second shunt element 1500. The wiring connecting the resistance element 131 included in the first shunt element 1300 and the pad 141 can also be considered in the same manner.

(77) FIG. 9A is a diagram illustrating an example of a configuration in which the wiring 153 has bent portions. In the example illustrated in FIG. 9A, the wiring 153 is configured to include the bent portions having two 90-degree bent portions. The inductance of the wiring 153 in the example illustrated in FIG. 9A can be calculated by dividing the wiring 153 into three rectangular portions. The three rectangular portions are a first rectangular portion RS1 connected to the pad 161, a second rectangular portion RS2 connected to the first rectangular portion, and a third rectangular portion RS3 connected to the second rectangular portion. The third rectangular portion RS3 is connected to the resistance element 151. The first rectangular portion RS1 has a length 121, a width w1, and a thickness h1, the second rectangular portion RS2 has a length 122, a width w2, and a thickness h2, and the third rectangular portion RS3 has a length 123, a width w3, and a thickness h3. Using Expression (5), respective inductances of the individual rectangular portions are calculated, and a total thereof is assumed to be the inductance of the wiring 153.

(78) An example of a method of determining the lengths 121, 122, and 123 will be described. It is assumed that a point of intersection of a line X passing through a middle of the first rectangular portion RS1 in a width direction and extending in a length direction and a line Y passing through a middle of the second rectangular portion RS2 in the width direction and extending in the length direction is a point A. It is also assumed that a point of intersection of the line Y and a line Z passing through a middle of the third rectangular portion RS3 in the width direction and extending in the length direction is a point B. Then, it is assumed that a distance between the end portion of the pad 161 and the point A is the length 121 of the first rectangular portion, a distance between the point A and the point B is the length 122 of the second rectangular portion RS2, and a distance between the point B and an end portion of the resistance element 151 is the length 123 of the third rectangular portion RS3.

(79) As the method of determining the length 121, the length 122, and the length 123, a determination method other than that described above may also be adopted as long as the wiring 153 is divided, and the rectangular portions can be specified.

(80) Next, FIG. 9B is a diagram illustrating an example in which the wiring 153 is configured to

linearly extend, while a width thereof gradually increases from the resistance element **151** toward the pad **161**. Even with the wiring **153** thus configured, by replacing the wiring **153** with a rectangular portion **RS4** as illustrated in the figure, it is possible to calculate the inductance of the wiring **153** by using Expression (5). The rectangular portion **RS4** has a length **124**, a width **w4**, and a thickness **h4**.

(81) Next, an example of a method of determining the length **124** and the width **w4** of the rectangular portion **RS4** will be described. A center point **C** of a portion **V-V'** along which the wiring **153** and the pad **161** are in contact is defined, and a point **D** which allows contact with the resistance element **151**, while having a shortest distance to the point **C**, is defined. It is assumed that the distance between the point **C** and the point **D** is the length **124**. It is also assumed that a distance between end portions of the wiring in a direction perpendicular to a line segment **CD** via a middle **E** between the point **C** and the point **D** is the width **w4**.

(82) Thus, according to the determination method described using FIGS. **9A** and **9B**, the inductance of the wiring can be calculated.

(83) According to the present embodiment, by configuring the shunt elements so as to satisfy Expression (1), Expression (2), and Expression (3), the parasitic oscillation can be suppressed. In addition, when the inductance **L** of the path connecting the first shunt element **1300** and the second shunt element **1500**, which is used in Expression (3), is determined, it is possible to apply the calculation methods described using Expression (4), Expression (5), FIG. **8**, and FIG. **9**.

#### Second Embodiment

(84) Using FIG. **10**, a description will be given of an antenna device according to the second embodiment of the present disclosure. In the second embodiment, unlike in the first embodiment, a pad and a pad are connected with a plurality of bonding wires. Note that, in the present embodiment, a description of the same components as those in the first embodiment is omitted.

(85) In an antenna device **200** illustrated in FIG. **10**, a chip **21** includes a pad **241** for applying a bias voltage and a pad **242** that applies a ground voltage. In addition, a substrate **20** includes a pad **261** for connection to the pad **241** of the chip **21** and a pad **262** for connection to the pad **242** of the chip **21**. The substrate **20** also has a plurality of bonding wires **291** for connecting the pad **241** and the pad **261** and a plurality of bonding wires **292** for connecting the pad **242** and the pad **262**.

Besides these, an antenna array, a first shunt element, a second shunt element, and the like in the antenna device **200** are the same as those in the antenna device **100** in the first embodiment.

(86) To reduce inductances of the bonding wires **291** and **292**, it is preferable to arrange the pad **241** and the pad **261** as well as the pad **242** and the pad **262** adjacent to each other and thereby shorten the bonding wires **291** and **292**.

(87) To shorten the bonding wires **291** and **292**, the pad **241** and the pad **242** are preferably placed on end portions of the chip **21**. When it is assumed that a side of the chip **21** traversed by the plurality of bonding wires **291** and **292** is a first side **271**, the pad **241** and the pad **261** are arranged so as to face each other with the first side **271** being interposed therebetween. In addition, the pad **242** and the pad **262** are also arranged so as to face each other with the first side **271** being interposed therebetween. Furthermore, the plurality of bonding wires **291** and **292** are arranged side by side to be spaced apart from each other in a direction parallel to the first side **271**.

(88) The plurality of bonding wires **291** and **292** are electrically connected in parallel. A combined inductance **L<sub>m</sub>** of **M** bonding wires connected in parallel can be calculating using Expression (6) below.

$$1/L_m = \sum (1/L_i) (i=1,2,3, \dots, M) \quad (6)$$

where **L<sub>i</sub>** is an inductance of the *i*-th bonding wire among the **M** bonding wires and, when the bonding wires have circular cross sections, the calculation is performed using Expression (4) while, when the bonding wires have quadrilateral cross sections, the calculation is performed using Expression (5). Note that whether the bonding wires have the circular cross sections or the quadrilateral cross sections may be determined as appropriate, and the combined inductance **L<sub>m</sub>** of

the bonding wires may appropriately be calculated using Expressions (4) and (5).

(89) By thus electrically connecting the plurality of bonding wires **291** and **292** in parallel, it is possible to reduce the combined inductance of the bonding wires **291** and **292** and thereby allow easy suppression of parasitic oscillation.

(90) In the present embodiment, areas of the pads **241** and **242** are set larger than those of the pads **141** and **142** in the first embodiment, and areas of the pads **261** and **262** are set larger than those of the pads **161** and **162** in the first embodiment. Thus, it is possible to increase the number of the bonding wires providing connection between the pads and reduce the combined inductance of the plurality of bonding wires.

(91) The pads **241**, **242**, **261**, and **262** are configured such that dimensions thereof in directions parallel to the first side **271** of the chip **21** are larger than dimensions thereof in directions perpendicular to the first side **271**. This can increase the number of the bonding wires that can be placed and reduce the combined inductance of the bonding wires.

(92) In the same manner as in the first embodiment, it is also possible to divide the pads **241**, **242**, **261**, and **262** on a per bonding wire basis. In this case, it is only required to provide a configuration in which connection is provided with a wiring layer underlying a metal layer forming the pads. However, such a configuration as illustrated in FIG. **10** in which a plurality of bonding wires are placed on one pad avoids the need to ensure spaces separating the pads, and allows easy pattern formation. Accordingly, by adopting the configuration illustrated by way of example in FIG. **10**, it is possible to use a low-cost printed substrate or ceramic package as the substrate **20** and allow a cost reduction.

### Third Embodiment

(93) Using FIG. **11**, a description will be given of an antenna device according to the third embodiment of the present disclosure. The third embodiment is different from the first embodiment in that additional resistance elements and capacitance elements are included in a first shunt element and a second shunt element to be connected in parallel. In the present embodiment, a description of the same components as those in the first and second embodiments is omitted.

(94) In an antenna device **300** in the present embodiment illustrated in FIG. **11**, a chip **31** includes a first shunt element including a resistance element **331** and a capacitance element **332** and another first shunt element including a resistance element **333** and the capacitance element **332**. In addition, in the antenna device **300**, the chip **31** includes pads **341** and **343** for applying a bias voltage and a pad **342** that applies a ground voltage. Furthermore, a substrate **30** includes a second shunt element including a resistance element **351** and a capacitance element **352** and another second shunt element including a resistance element **353** and a capacitance element **354**.

(95) The substrate **30** also includes a pad **361** for connection to the pad **341** of the chip **31**, a pad **362** for connection to the pad **342** of the chip **31**, and a pad **363** for connection to the pad **343** of the chip **31**. The pad **341** and the pad **361** are connected with a bonding wire **391**, the pad **342** and the pad **362** are connected with a bonding wire **392**, and the pad **343** and the pad **363** are connected with a bonding wire **393**. The substrate **30** further includes connection terminals **381** and **383** to which the bias voltage is applied from a voltage bias circuit **37** and the connection terminal **382** that gives the ground voltage.

(96) In FIG. **11**, the pads **341**, **342**, and **343** of the chip **31** and the pads **361**, **362**, and **363** of the substrate **30** are connected, on a one-to-one basis, with the respective bonding wires **391**, **392**, and **393**. However, as in the second embodiment, the two pads may also be connected with a plurality of bonding wires. Alternatively, as illustrated in FIG. **3**, the two pads may also be connected with through electrodes instead of using the bonding wires **391**, **392**, and **393**.

(97) An antenna array **32** is placed at substantially a center of the chip **31** in the same manner as in the first embodiment, and the capacitance element **332** is placed adjacent to the antenna array **32**. One terminal of the resistance element **331** is connected to one terminal of the capacitance element **332** via wiring and a via (not shown). One terminal of the resistance element **333** is connected to

one terminal of the capacitance element **332** via wiring and a via (not shown). The resistance elements **331** and **333** are preferably placed in the vicinity of the capacitance element **332**. Alternatively, the resistance elements **331** and **333** may also be placed on the capacitance element **332** in overlapping relation thereto. Another terminal of the resistance element **331** is connected to the pad **341** via a bias voltage line **330**. The bias voltage line **330** is placed also between individual antennas **321** of the antenna array **32** to be connected to each of the antennas **321**. Thus, the bias voltage is applied to each of the antennas **321**. Another terminal of the capacitance element **332** is connected to the pad **342** via wiring and a via (not shown). Another terminal of the resistance element **333** is connected to the pad **343** via the bias voltage line **330**.

(98) One terminal **3512** of the resistance element **351** is connected to the one terminal **3521** of the capacitance element **352** via wiring. In other words, the resistance element **351** and the capacitance element **352** are connected in series. Accordingly, the resistance element **351** and the capacitance element **352** are preferably arranged adjacent to each other. More preferably, the one terminal **3512** of the resistance element **351** is placed adjacent to the one terminal **3521** of the capacitance element **352** to be able to shorten the wiring and reduce the inductance.

(99) Another terminal **3511** of the resistance element **351** is connected to the pad **361** via wiring and also connected to the connection terminal **381** via the wiring. Meanwhile, another terminal **3522** of the capacitance element **352** is connected to the pad **362** via wiring, and is also connected to a connection terminal **382** via wiring.

(100) One terminal **3532** of the resistance element **353** is connected to one terminal **3541** of the capacitance element **354** via wiring. In other words, the resistance element **353** and the capacitance element **354** are connected in series. Accordingly, the resistance element **353** and the capacitance element **354** are preferably arranged adjacent to each other. More preferably, the one terminal **3532** of the resistance element **353** and the one terminal **3541** of the capacitance element **354** are arranged adjacent to each other to be able to shorten the wiring and reduce the inductance.

(101) Another terminal **3531** of the resistance element **353** is connected to the pad **363** via wiring, and is also connected to the connection terminal **383** via wiring. Meanwhile, another terminal **3542** of the capacitance element **354** is connected to the pad **362** via wiring, and is also connected to the connection terminal **382** via wiring.

(102) In FIG. **11**, the terminals **3511** and **3512** of the resistance element **351**, the terminals **3521** and **3522** of the capacitance element **352**, the terminals **3531** and **3532** of the resistance element **353**, and the terminals **3541** and **3542** of the capacitance element **354** are arranged side by side in one direction (left-right direction in the figure) over the substrate **30**. In the present embodiment, the pads **361**, **362**, and **363** are also arranged side by side in the same direction as the direction in which the terminals **3511**, **3512**, **3521**, **3522**, **3531**, **3532**, **3541**, and **3542** are arranged. By thus arranging the terminals and the pads, it is possible to shorten the connecting wiring and reduce the inductance.

(103) Since the bias voltage is supplied from the voltage bias circuit **37** to both of the connection terminals **381** and **383**, the other terminal **3511** of the resistance element **351** and the other terminal **3531** of the resistance element **353** are electrically connected. Meanwhile, the other terminal **3522** of the capacitance element **352** and the other terminal **3542** of the capacitance element **354** are commonly connected via the wiring. As a result, the resistance element **351** and the capacitance element **352** each included in the second shunt element and the resistance element **353** and the capacitance element **354** each included in the other second shunt element are electrically connected in parallel. As each of the resistance elements **351** and **353** and the capacitance elements **352** and **354**, e.g., a SMD (Surface Mount Device) is adopted, and such a component has not only a resistive component and a capacitive component, but also a parasitic inductance. Accordingly, in two pairs of the first shunt elements and the second shunt elements, the second shunt elements in the respective pairs (the resistance element **351**, the capacitance element **352**, the resistance element **353**, and the capacitance element **354**) are connected in parallel. Thus, it is possible to



reduce the parasitic inductance and suppress the parasitic oscillation.

(104) In addition, since the bonding wire **391** and the bonding wire **393** each serving as a path that supplies the bias voltage are connected in parallel, a combined inductance of the bonding wires is also reduced.

(105) Moreover, since the wiring placed in the substrate **30** also has a resistance value, as each of the resistance elements **351** and **353**, a resistance of the wiring in the substrate **30** connecting the first shunt elements and the second shunt elements may also be used. This can reduce the number of components to be placed over the substrate **30**, which is advantageous for a size reduction.

(106) In the chip **31**, the elements and pads that are arranged over the chip **31** and the elements, pads, wiring, and the like arranged over the substrate **30** are arranged symmetrically with respect to an axis passing through a center of the antenna array **32**. Examples of the axis passing through the center of the antenna array **32** include an axis AX extending in a direction perpendicular to the top surface of the substrate **30** and an axis extending in a direction parallel to the top surface of the substrate **30**. Symmetricity is determined herein on the basis of the axis extending in the direction parallel to the top surface of the substrate. The center of the antenna array **32** can be determined on the basis of a planar shape of the conductor of the antenna array **32**. The center of the antenna array **32** may also be a gravity center of the conductor of the antenna array **32**. The gravity center can be determined on the basis of a cross-sectional shape and a planar shape. Therefore, in the substrate **30**, the plurality of pairs of the first shunts and the second shunt elements which are connected to each other are arranged, and at least two of the pairs of the first shunt elements and the second shunt elements are placed at positions symmetrical to each other with respect to the axis passing through the center of the antenna array. This improves a directionality of a terahertz wave generated from the antenna array **32** and enhances a frontal intensity of the terahertz wave.

(107) In the present embodiment, a configuration is adopted in which the bias voltage is supplied from two paths using the connection terminals **381** and **383**, and the ground voltage is given from one path using the connection terminal **182**. However, it may also be possible to use a configuration in which the ground voltage is given from the two paths using the connection terminals **381** and **383**, and the bias voltage is supplied from the one path using the connection terminal **182**.

#### Fourth Embodiment

(108) Using FIGS. **12** to **14**, a description will be given of an antenna device according to the fourth embodiment of the present disclosure. The antenna device according to the fourth embodiment is different from the antenna device according to the first embodiment in that pads are arranged on both sides on which two facing sides of a chip are present, i.e., the pads and the chip are arranged such that the chip is interposed between the pads. In the present embodiment, a description of the same components as those in the embodiments described above is omitted.

(109) In an antenna device **400** according to the present embodiment illustrated in FIG. **12**, a chip **41** includes, in the same manner as in the first embodiment, a pad **441** for applying a bias voltage and a pad **442** that applies a ground voltage. In addition, unlike in the first embodiment, the antenna device **400** includes a pad **443** for applying the bias voltage and a pad **444** for applying the ground voltage.

(110) On the chip **41**, the pads **441** and **442** are arranged on a side on which a first side **411** of the chip **41** is present when viewed from an antenna array **42**. Meanwhile, on the chip **41**, the pad **443** and the pad **444** are arranged on a side on which a second side **412** of the chip **41** facing the first side **411** is present when viewed from the antenna array **42**. This results in a configuration in which, between the pads **441** and **442** and the pads **443** and **444**, an antenna array **42** is placed. Thus, the two pairs of the first shunt elements and the second shunt elements are arranged such that the antenna array is interposed between the respective pairs of the first shunt elements and the second shunt elements.

(111) In addition, in the chip **41**, a resistance element **431**, a capacitance element **432**, and a

resistance element **433** which are included in the first shunt element are arranged.

(112) One terminal of the resistance element **431** is connected to one terminal of the capacitance element **432** via wiring and a via (not shown). Preferably, the resistance element **431** is placed in the vicinity of the capacitance element **432**. Alternatively, the resistance element **431** may also be placed on the capacitance element **432** in overlapping relation thereto. Meanwhile, another terminal of the resistance element **431** is connected to the pad **441** via a bias voltage line **430**. The bias voltage line **430** is placed also between the individual antennas **421** of the antenna array **42** to be connected commonly to the individual antennas **421**, and the bias voltage is applied to each of the antennas **421**.

(113) One terminal of the resistance element **433** is connected to one terminal of the capacitance element **432** via wiring and a via (not shown). Preferably, the resistance element **433** is placed in the vicinity of the capacitance element **432**. Alternatively, the resistance element **433** may also be placed on the capacitance element **432** in overlapping relation thereto. Meanwhile, another terminal of the resistance element **433** is connected to the pad **443** via the bias voltage line **430**. Another terminal of the capacitance element **432** is connected to the pads **442** and **444** via wiring a vias (not shown).

(114) On the chip **41**, between the pads **441** and **442** and the pads **443** and **444**, the resistance element **431** and the resistance element **433** are arranged. Meanwhile, between the resistance element **431** and the resistance element **433**, the antenna array **42** around which the capacitance element **432** is placed is placed. Thus, the pads and the first shunt element are arranged symmetrically with respect to an axis passing through a center of the antenna array **42** (an axis BX extending in a direction perpendicular to a top surface of the substrate **40**). Therefore, in the substrate **40**, the plurality of pairs of the first shunts and the second shunt elements which are connected to each other are arranged, and at least two of the pairs of the first shunt elements and the second shunt elements are arranged at positions symmetrical to each other with respect to the axis passing through the center of the antenna array. This improves a directionality of a terahertz wave generated from the antenna array **42** and enhances a frontal intensity of the terahertz wave.

(115) In the substrate **40**, in a first region **413** (region surrounded by a dotted line in the figure) present on the side of the chip **41** with the first side **411**, in the same manner as in the first embodiment, a resistance element **451** and a capacitance element **452** each included in the second shunt element are arranged. In addition, in the first region **413**, a pad **461** to be connected to the pad **441** of the chip **41** with a bonding wire **491** and a pad **462** to be connected to the pad **442** of the chip **41** with a bonding wire **492** are arranged. Furthermore, in the first region **413**, a connection terminal **481** to which the bias voltage is to be supplied from a voltage bias circuit **471** and a connection terminal **482** that gives the ground voltage are arranged.

(116) Also, in the substrate **40**, in a second region **414** (region surrounded by a dotted line in the figure) present on the side of the chip **41** with the second side **412**, a resistance element **453** and a capacitance element **454** each included in the second shunt element are arranged. In addition, in the second region **414**, a pad **463** to be connected to the pad **443** of the chip **41** with a bonding wire **493** and a pad **464** to be connected to the pad **444** of the chip **41** with a bonding wire **494** are arranged. Furthermore, in the second region **414**, a connection terminal **483** to which the bias voltage is to be supplied from a voltage bias circuit **472** and a connection terminal **484** that gives the ground voltage are arranged.

(117) In the description given above, the voltage bias circuits **471** and **472** are provided as separate circuits, but the substrate **40** may also be configured such that one voltage bias circuit supplies the bias voltage and the ground voltage.

(118) Thus, the substrate **40** has a configuration in which the chip **41** is placed between the first region **413** and the second region **414**. In this configuration, between the pads **441** and **442** and the pads **443** and **444**, the antenna array **42** is placed. In other words, in a direction along a line segment connecting the side **411** and the side **412**, the first region **413**, the chip **41**, and the second

region **414** are arranged in this order. Such a configuration can reduce the impedance of the wiring that supplies the bias voltage. In addition, between the resistance element **451** or the capacitance element **452** and the resistance element **453** or the capacitance element **454**, the chip **41** is placed. As a result, in the same manner as in the case of the first shunt elements, the pads and the second shunt elements are arranged symmetrically with respect to the axis passing through the center of the antenna array **42**. Examples of the axis passing through the center of the antenna array **42** include the axis BX extending in the direction perpendicular to the top surface of the substrate **40** and an axis extending in a direction parallel to the top surface of the substrate **40**. Symmetricity is determined herein on the basis of the axis extending in the direction parallel to the top surface of the substrate. Therefore, in the substrate **40**, the plurality of pairs of the first shunts and the second shunt elements which are connected to each other are arranged, and at least two of the pairs of the first shunt elements and the second shunt elements are arranged at positions symmetrical to each other with respect to the axis passing through the center of the antenna array. This improves the directionality of the terahertz wave generated from the antenna array **42** and enhances the frontal intensity of the terahertz wave.

(119) In addition, according to the present embodiment, the bias voltage to be applied to the antenna array **42** is supplied from the side of the chip **41** with the two facing sides **411** and **412**. As a result, the impedance of the wiring that supplies the bias voltage is smaller than in a case where the bias voltage is supplied from a side of the chip **41** with any one of the sides, and accordingly a voltage drop is reduced. Consequently, antenna-to-antenna variation in the bias voltage to be applied to the negative differential resistance element of each of the antennas decreases to improve uniformities of antenna outputs.

(120) In addition, the resistance element **451** and the capacitance element **452** and the resistance element **453** and the capacitance element **454**, which are included in the second shunt elements, are connected in parallel. As each of the resistance elements **451** and **453** and the capacitance elements **452** and **454**, e.g., the SMD is adopted, and such a component has not only a resistive component and a capacitive component, but also a parasitic inductance. Accordingly, by connecting the resistance element **451** and the capacitance element **452** and the resistance element **453** and the capacitance element **454** in parallel, it is possible to reduce the parasitic inductance and suppress the parasitic oscillation.

(121) Moreover, since the wiring placed in the substrate **40** also has a resistance value, as each of the resistance elements **451** and **453**, a resistance of the wiring may also be used, and the number of components to be placed over the substrate **40** can thus be reduced, which is advantageous for a size reduction.

(122) FIG. **13** is a diagram illustrating an antenna device according to a modification of the present embodiment. Note that, in the present modification, a description of the same components as those in the embodiments described above is omitted. A configuration of an antenna device **500** illustrated in FIG. **13** corresponds to a configuration obtained by further applying characteristic features of the present embodiment to the configuration illustrated in the third embodiment. In the present modification, the same components as those in the third embodiment are denoted by the same reference signs, and a description thereof is omitted.

(123) In the antenna device **500**, on a side of a top surface of a chip **51** on which a first side **511** of the chip **51** is present, resistance elements **531** and **533** and pads **541**, **542**, and **543** are arranged in the same manner as in the third embodiment. Meanwhile, on a side of the chip **51** on which a second side **512** thereof facing the first side **511** is present, resistance elements **534** and **535** and pads **544**, **545**, and **546** are arranged.

(124) Between the first side **511** and the second side **512** of the chip **51**, an antenna array **52** in which a plurality of antennas **521** are arranged is placed. Around the antenna array **52**, the capacitance element **532** is placed. The capacitance element **532** is connected to each of the resistance elements **531**, **533**, **534**, and **535** to be included in a first shunt element.

(125) Respective one terminals of the resistance elements **531**, **533**, **534**, and **535** are connected to one terminal of the capacitance element **532** via wiring and vias (not shown). The resistance elements **531**, **533**, **534**, and **535** are preferably arranged in the vicinity of the capacitance element **532**. Alternatively, the resistance elements **531**, **533**, **534**, and **535** may also be placed on the capacitance element **532** in overlapping relation thereto. Respective other terminals of the resistance elements **531**, **533**, **534**, and **535** are connected to the pad **541** via a bias voltage line **530**. The bias voltage line **530** is placed also between the individual antennas **521** in the antenna array **52** to be connected commonly to the individual antennas **521**, and a bias voltage is applied to each of the antennas **521**. Another terminal of the capacitance element **532** is connected to the pads **542** and **545** via wiring and vias (not shown).

(126) On the chip **51**, between the pads **541**, **542**, and **543** and the pads **544**, **545**, and **546**, the resistance elements **531** and **533** and the resistance elements **534** and **535** are arranged. In addition, between the resistance elements **531** and **533** and the resistance elements **534** and **535**, the antenna array **52** around which the capacitance element **532** is placed is placed. Thus, the pads and the first shunt elements are arranged symmetrically with respect to an axis passing through a center of the antenna array **52**. Examples of the axis passing through the center of the antenna array **52** include an axis **CX** extending in a direction perpendicular to a top surface of a substrate **50** and an axis extending in a direction parallel to the top surface of the substrate **50**. Symmetricity is determined herein on the basis of the axis extending in the direction parallel to the top surface of the substrate. Therefore, in the substrate **50**, the plurality of pairs of the first shunts and second shunt elements which are connected to each other are arranged, and at least two of the pairs of the first shunt elements and the second shunt elements are arranged at positions symmetrical to each other with respect to the axis passing through the center of the antenna array. This improves a directionality of a terahertz wave generated from the antenna array **52** and enhances a frontal intensity of the terahertz wave.

(127) In the substrate **50**, in a first region **513** (region surrounded by a dotted line in the figure) present on the side of the chip **51** with the first side **511**, in the same manner as in the third embodiment, a pad **561** to be connected to the pad **541** of the chip **51** with a bonding wire **591** is placed. In addition, in the first region **513**, a pad **562** to be connected to the pad **542** with a bonding wire **592** and a pad **563** to be connected to the pad **543** with a bonding wire **593** are arranged. Moreover, in the first region **513**, resistance elements **551** and **553** and capacitance elements **552** and **554** which are included in the second shunt elements are arranged. Furthermore, in the first region **513**, connection terminal **581** and **583** to which the bias voltage is to be supplied from a voltage bias circuit **571** as well as a connection terminal **582** that gives the ground voltage are arranged. Note that mutual connection relationships between the individual pads, the second shunt elements, and the connection terminals are the same as the connection relationships described in the third embodiment.

(128) In the description given above, the voltage bias circuits **571** and **572** are provided as separate circuits, but the substrate **50** may also be configured such that one voltage bias circuit supplies the bias voltage and the ground voltage.

(129) Also, in the substrate **50**, in a second region **514** (region surrounded by a dotted line in the figure) present on the side of the chip **51** with the second side **512**, a pad **564** to be connected to the pad **544** of the chip **51** with a bonding wire **594** is placed. In addition, in the second region **514**, a pad **565** to be connected to the pad **545** with a bonding wire **595** and a pad **566** to be connected to the pad **546** with a bonding wire **596** are arranged. Moreover, in the second region **514**, resistance elements **555** and **557** and capacitance elements **556** and **558** which are included in the second shunt elements are arranged. Furthermore, in the second region **514**, connection terminal **584** and **586** to which the bias voltage is to be supplied from the voltage bias circuit **572** as well as a connection terminal **585** that gives the ground voltage are arranged. Note that connection relationships among the individual pads, the second shunt elements, and the connection terminals

in the second region **514** are also the same as the connection relationships described in the third embodiment.

(130) Thus, the substrate **50** has a configuration in which the chip **51** is placed between the first region **513** and the second region **514**. In this configuration, between the pad **541** and the pad **544**, between the pad **542** and the pad **545**, or between the pad **543** and the pad **546**, the antenna array **52** is placed. In addition, between the resistance elements **551** and **553** and the capacitance elements **552** and **554** and between the resistance elements **555** and **557** and the capacitance elements **556** and **558**, the chip **51** is placed. As a result, the pads and the second shunt elements are arranged symmetrically with respect to the axis passing through the center of the antenna array **52**. Examples of the axis passing through the center of the antenna array **52** include the axis CX extending in the direction perpendicular to the top surface of the substrate **50** and an axis extending in a direction parallel to the top surface of the substrate **50**. Symmetry is determined herein on the basis of the axis extending in the direction parallel to the top surface of the substrate. Therefore, in the substrate **50**, the plurality of pairs of the first shunts and the second shunt elements which are connected to each other are arranged, and at least two of the pairs of the first shunt elements and the second shunt elements are arranged at positions symmetrical to each other with respect to the axis passing through the center of the antenna array. This improves a directionality of a terahertz wave generated from the antenna array **52** and enhances a frontal intensity of the terahertz wave.

(131) In addition, by supplying the bias voltage from the two facing sides **511** and **512** of the chip **51**, the impedance of the wiring that supplies the bias voltage decreases, and accordingly a voltage drop is reduced. Consequently, antenna-to-antenna variation in the bias voltage to be applied to the negative differential resistance element of each of the antennas decreases to improve uniformities of antenna outputs.

(132) In addition, the resistance element **551** and the capacitance element **552** and the resistance element **553** and the capacitance element **554**, which are included in the second shunt element, are connected in parallel. Likewise, the resistance element **555** and the capacitance element **556** and the resistance element **557** and the capacitance element **558**, which are included in the second shunt element, are connected in parallel. Accordingly, in the antenna device **500**, the number of the resistance elements and the capacitance elements which are connected in parallel is larger than that in the antenna device **400**. Therefore, it is possible to further reduce the parasitic inductance included in the resistance elements and the capacitance elements and suppress the parasitic oscillation.

(133) Moreover, since the wiring placed in the substrate **50** also has a resistance value, as each of the resistance elements **551**, **553**, **555**, and **557**, a resistance of the wiring may also be used, and the number of components to be placed over the substrate **50** can thus be reduced, which is advantageous for a size reduction.

(134) FIG. **14** is a diagram illustrating an antenna device according to a modification of the present embodiment. A configuration of an antenna device **600** illustrated in FIG. **14** corresponds to a configuration obtained by further applying characteristic features of the second embodiment to the configuration of the antenna device **500** illustrated in FIG. **13**. Accordingly, the antenna device according to the present modification is characterized in that the number of the bonding wires providing connection between the pads in the antenna device described above is different. In the configuration of the antenna device illustrated in FIG. **14**, a description of the same components as those of the antenna device **500** illustrated in FIG. **13** is omitted.

(135) As illustrated in FIG. **14**, in the antenna device **600**, on a side of a top surface of a chip **61** on which a first side **611** of the chip **61** is present, pads **641**, **642**, and **643** are arranged. In addition, on a side of the chip **61** on which a second side **612** thereof facing the first side **611** is present, pads **644**, **645**, and **646** are arranged.

(136) In a substrate **60**, in a first region **613** (region surrounded by a dotted line in the figure) present on the side of the chip **61** with the first side **611**, pads **661**, **662**, and **663** are arranged, in the

same manner as in the configuration illustrated in FIG. 13. Meanwhile, in a second region **614** (region surrounded by a dotted line in the figure) of the chip **61** present on the side with the second side **612**, pads **664**, **665**, and **666** are arranged.

(137) The pad **641** and the pad **661** are connected with a plurality of bonding wires **691**, the pad **642** and the pad **662** are connected with a plurality of bonding wires **692**, and the pad **643** and the pad **663** are connected with a plurality of bonding wires **693**. Meanwhile, the pad **644** and the pad **664** are connected with a plurality of bonding wires **694**, the pad **645** and the pad **665** are connected with a plurality of bonding wires **695**, and the pad **646** and the pad **666** are connected with a plurality of bonding wires **696**.

(138) In the present modification also, in the same manner as in the second embodiment, by electrically connecting the plurality of bonding wires in parallel, it is possible to reduce a combined inductance of the bonding wires, and suppress parasitic oscillation.

#### Fifth Embodiment

(139) Next, using FIGS. 15 and 16, a description will be given of an antenna device according to the fifth embodiment of the present disclosure. The antenna device according to the fifth embodiment is characterized in that pads are arranged in the vicinity of individual sides of a chip. In the present embodiment, a description of the same components as those in the other embodiments is omitted.

(140) In an antenna device **700** according to the present embodiment illustrated in FIG. 15, a chip **71** includes pads **741** and **743** for applying a bias voltage and a pad **742** that applies a ground voltage. The antenna device **700** further includes the pad **741** for applying the bias voltage and the pad **742** that applies the ground voltage.

(141) In the antenna device **700** according to the present embodiment, on the chip **71**, the pad **741** is placed in the vicinity of a first side **711**, while the pad **742** is placed in the vicinity of a second side **712**. Also, on the chip **71**, the pad **743** is placed in the vicinity of a third side **713** facing the first side **711**, while a pad **744** is placed in the vicinity of a fourth side **714** facing the second side **712**. To each of the pad **741** and the pad **743**, the bias voltage is applied while, to each of the pad **742** and the pad **744**, the ground voltage is applied. The pads **741**, **742**, **743**, and **744** are arranged around an antenna array **72** so as to surround the antenna array **72**.

(142) In the chip **71**, resistance elements **731** and **733** and a capacitance element **732**, which are included in a first shunt element, are arranged. One terminal of the resistance element **731** and one terminal of the resistance element **733** are connected to one terminal of the capacitance element **732** via wiring and vias (not shown). Preferably, the resistance element **731** and the resistance element **733** are arranged adjacent to the capacitance element **732**. Alternatively, the resistance element **731** may also be placed on the capacitance element **732** in overlapping relation thereto. Another terminal of the resistance element **731** is connected to the pad **741** via a bias voltage line **730**, while another terminal of the resistance element **733** is connected to the pad **743** via the bias voltage line **730**. The bias voltage line **730** is placed also between the individual antennas **721** in the antenna array **72** to be connected commonly to the individual antennas **721**, and the bias voltage is applied. Another terminal of the capacitor **732** is connected to each of the pad **742** and the pad **744** via wiring and a via (not shown).

(143) In a substrate **70**, in a first region **715** present on a side of the chip **71** with the first side **711**, a resistance element **751** and a capacitance element **758** which are included in a second shunt element and a pad **761** to be connected to the pad **741** of the chip **71** with a bonding wire **791** are arranged. In addition, in the first region **715**, a connection terminal **781** to which the bias voltage is to be supplied from a voltage bias circuit **771** is placed. One terminal of the resistance element **751** and one terminal of the capacitance element **758** are connected to the pad **761**, and the pad **761** is connected to the connection terminal **781**.

(144) Likewise, in a second region **716** present on a side of the chip **71** with the second side **712**, a capacitance element **752** and a resistance element **753**, which are included in the second shunt

element, and a pad **762** to be connected to the pad **742** of the chip **71** with a bonding wire **792** are arranged. In addition, in the second region **716**, a connection terminal **782** to which the ground voltage is to be supplied from a voltage bias circuit **772** is placed. One terminal of the capacitance element **752** and one terminal of the resistance element **753** are connected to the pad **762**, and the pad **762** is connected to the connection terminal **782**.

(145) Likewise, in a third region **717** present on a side of the chip **71** with the third side **713**, a capacitance element **754** and a resistance element **755**, which are included in the second shunt element, and a pad **763** to be connected to the pad **743** of the chip **71** with a bonding wire **793** are arranged. In addition, in the third region **717**, a connection terminal **783** to which the bias voltage is to be supplied from a voltage bias circuit **773** is placed. One terminal of the capacitance element **754** and one terminal of the resistance element **755** are connected to the pad **763**, and the pad **763** is connected to the connection terminal **783**.

(146) Likewise, in a fourth region **718** present on a side of the chip **71** with the fourth side **714**, a capacitance element **756** and a resistance element **757**, which are included in the second shunt element, and a pad **764** to be connected to the pad **744** of the chip **71** with a bonding wire **794** are arranged. In addition, in the fourth region **718**, a connection terminal **784** to which the ground voltage is to be supplied from a voltage bias circuit **774** is placed. One terminal of the capacitance element **756** and one terminal of the resistance element **757** are connected to the pad **764**, and the pad **764** is connected to the connection terminal **784**.

(147) In the vicinity of a first corner **726** formed between the first side **711** and the second side **712** of the chip **71**, the resistance element **751** and the capacitance element **752** are arranged, and another terminal of the resistance element **751** and another terminal of the capacitance element **752** are connected. Meanwhile, in the vicinity of a second corner **727** formed between the second side **712** and the third side **713** of the chip **71**, the resistance element **753** and the capacitance element **754** are arranged, and another terminal of the resistance element **753** and another terminal of the capacitance element **754** are connected. In addition, in the vicinity of a third corner **728** formed between the third side **713** and the fourth side **714** of the chip **71**, the resistance element **755** and the capacitance element **756** are arranged, and another terminal of the resistance element **755** and another terminal of the capacitance element **756** are connected. Meanwhile, in the vicinity of a fourth corner **729** formed between the fourth side **714** and the first side **711** of the chip **71**, the resistance element **757** and the capacitance element **758** are arranged, and another terminal of the resistance element **757** and another terminal of the capacitance element **758** are connected.

(148) Through connection relationships between the resistance elements and the capacitance elements, the resistance elements **751** and the capacitance element **752**, the resistance element **753** and the capacitance element **754**, the resistance element **755** and the capacitance element **756**, and the resistance element **757** and the capacitance element **758**, which are included in the second shunt elements, are electrically connected in parallel to each other. This can further reduce the parasitic inductance included in each of the elements and suppress the parasitic oscillation.

(149) In FIG. **15**, the voltage bias circuits **771**, **772**, **773**, and **774** are provided as the separate circuits, but the substrate **70** may also be configured such that the bias voltage and the ground voltage are supplied by one voltage bias circuit.

(150) Also, in FIG. **15**, the resistance element **751** and the capacitance element **752** each included in the second shunt element are arranged such that a direction in which the two terminals of the resistance element **751** are arranged and a direction in which the two terminals of the capacitance element **752** are arranged are perpendicular to each other. In addition, the resistance element **753** and the capacitance element **754**, the resistance element **755** and the capacitance element **756**, and the resistance element **757** and the capacitance element **758** are also configured to be similarly arranged.

(151) Moreover, since the wiring placed in the substrate **70** also has a resistance value, as each of the resistance elements **751**, **753**, **755**, and **757**, a resistance of the wiring may also be used, and the

number of components to be placed over the substrate **70** can thus be reduced, which is advantageous for a size reduction.

(152) Thus, in the present embodiment, on the sides of the chip **71** on which the four individual sides are present, the respective pads are arranged, and the bias voltage or the ground voltage is supplied from each of the sides. In other words, this configuration is as follows. In a direction along a line segment connecting the two facing sides, the pad, the chip **71**, and the pad are arranged in this order while, in a direction along a line segment connecting other facing two sides, the pad, the chip **71**, and the pad are arranged in this order. The direction along the line segment connecting the two facing sides and the direction along the line segment connecting the other two facing sides cross each other. Due to the configuration in the present embodiment, the impedance of the wiring that supplies the bias voltage becomes smaller than that in a case where the bias voltage or the ground voltage is supplied from the side of the chip **71** on which any one or two of the sides are present, and accordingly the voltage drive decreases. Consequently, antenna-to-antenna variation in the bias voltage to be applied to the negative differential resistance element of each of the antennas decreases to improve uniformities of antenna outputs.

(153) In addition, since the pads are arranged on the sides of the chip **71** on which the individual sides are present, it is possible to electrically connect the plurality of bonding wires in parallel, while increasing sizes of the pads. This can reduce the combined inductance of the bonding wires and further suppress the parasitic oscillation.

(154) Additionally, by arranging, over the substrate **70**, the resistance elements and the capacitance elements of the second shunt elements in the vicinities of the four corners **726** to **729** of the chip **71**, it is possible to effectively use the space of the substrate, reduce a substrate size, and thereby reduce manufacturing cost.

(155) The pads and the second shunt elements are arranged symmetrically with respect to an axis passing through a center of the antenna array **72**. Examples of the axis passing through the center of the antenna array **72** include an axis DX extending in a direction perpendicular to a top surface of the substrate **70** and an axis extending in a direction parallel to the top surface of the substrate **70**. Symmetry is determined herein on the basis of the axis extending in the direction parallel to the top surface of the substrate. Therefore, on the substrate **70**, the plurality of pairs of the first shunts and the second shunt elements which are connected to each other are arranged, and at least two of the pairs of the first shunt elements and the second shunt elements are arranged at positions symmetrical to each other with respect to the axis passing through the center of the antenna array. This improves a directionality of a terahertz wave generated from the antenna array **72** and enhances a frontal intensity of the terahertz wave.

(156) FIG. **16** is a diagram illustrating an antenna device according to a modification of the present embodiment. In the present modification, a description of the same components as those in the embodiments described above is omitted. In an antenna device **800** illustrated in FIG. **16**, in the vicinities of individual corners **826** to **829** of a chip **81**, a resistance element **851** and a capacitance element **852**, a resistance element **853** and a capacitance element **854**, a resistance element **855** and a capacitance element **856**, and a resistance element **857** and a capacitance element **858** are arranged. In addition, the resistance elements **851**, **853**, **855**, and **857** and the capacitance elements **852**, **854**, **856**, and **858** are arranged obliquely to respective directions in which individual sides of the chip extend. Moreover, a direction in which two terminals of the resistance element **851** are arranged is the same as a direction in which two terminals of the capacitance element **852** are arranged, and the resistance element **853** and the capacitance element **854**, the resistance element **855** and the capacitance element **856**, and the resistance element **857** and the capacitance element **858** are similarly arranged.

(157) Since the individual elements are thus arranged, it is possible to shorten wiring connecting the resistance elements, the capacitance elements, and the pads, reduce parasitic inductance included in the wiring, and suppress parasitic oscillation.



#### Sixth Embodiment

(158) Next, using FIGS. **17** to **22**, a description will be given of an antenna array in an antenna device according to the sixth embodiment of the present disclosure. In the present embodiment, a description of the same components as those in the other embodiments is omitted.

(159) FIG. **17** illustrates an equivalent circuit diagram of an antenna device **900** according to the present embodiment. An example of a configuration of the equivalent circuit diagram illustrated in FIG. **17** corresponds to the configuration in the equivalent circuit diagram of the antenna device **100** according to the first embodiment illustrated in FIG. **5**, in which the antennas **121** in the antenna array **12** are arranged in a  $3 \times 3$  matrix configuration. An antenna array **912** has  $3 \times 3$  negative differential resistance elements  $r_{11}$ ,  $r_{12}$ ,  $r_{13}$ ,  $r_{21}$ ,  $r_{22}$ ,  $r_{23}$ ,  $r_{31}$ ,  $r_{32}$ , and  $r_{33}$ , resistance elements  $R_{ai}$  ( $i=1, 2, 3, \dots, 12$ ), and capacitance elements  $C_{ai}$  ( $i=1, 2, 3, \dots, 12$ ). In the antenna array **912**, the negative differential resistance elements and a plurality of third shunt elements in which the resistance elements and the capacitance elements are connected in series are configured. In addition, the  $3 \times 3$  negative differential resistance elements and the plurality of third shunt elements are configured to be connected in parallel to each other. One terminals of the negative differential resistance elements, one terminals of the resistance elements  $R_{ai}$  in the plurality of third shunt elements, and one terminal of the resistance element  $R_c$  of a first shunt element are commonly connected. Meanwhile, other terminals of the resistance elements  $R_{ai}$  are connected to one terminals of the capacitance elements  $C_{ai}$ . Moreover, other terminals of the negative differential resistance elements and other terminals of the capacitance elements  $C_{ai}$  in the plurality of third shunt elements are connected to a ground potential. The other components of the antenna array **912** are the same as those in FIG. **5**, and therefore a description thereof is omitted herein.

(160) In the antenna array **912**, a combined resistance of the  $3 \times 3$  negative differential resistance elements  $r_{11}$ ,  $r_{12}$ ,  $r_{13}$ ,  $r_{21}$ ,  $r_{22}$ ,  $r_{23}$ ,  $r_{31}$ ,  $r_{32}$ , and  $r_{33}$  corresponds to the resistance  $r$  illustrated in FIG. **5**. Meanwhile, a combined impedance of parasitic impedances of the third shunt elements and wiring corresponds to the impedance  $Z$  illustrated in FIG. **5**.

(161) FIG. **18** is an example of a top view of the antenna array **912** disposed in a  $3 \times 3$  matrix configuration corresponding to the equivalent circuit diagram of FIG. **17**. FIG. **19** is a cross-sectional view along a line C-C' in FIG. **18**. A description of the configuration described using FIG. **4** is omitted, and the same components as those in FIG. **4** are denoted by the same reference signs. As described using FIG. **4**, the adjacent antennas are coupled to each other via microstrip lines **125a** to **125h**, and are in mutual injection locking (mutually synchronized) at an oscillation frequency  $f_{THz}$  of a terahertz wave. FIG. **18** illustrates an example of a configuration in which one antenna includes two negative differential resistance elements **127a** and **127b**. In order to improve a directionality of the terahertz wave, the two negative differential resistance elements **127a** and **127b** are preferably symmetrically arranged with respect to a line passing through a center of the one antenna.

(162) To suppress parasitic oscillation in a frequency band lower than the oscillation frequency  $f_{THz}$ , the bias voltage line **130** is provided with the third shunt elements. The third shunt elements are arranged in parallel to the negative differential resistance elements to provide a structure in which a short circuit is caused in a frequency band lower than  $f_{THz}$  to suppress the parasitic oscillation. Each of the third shunt elements has a structure in which the resistance element or an element obtained by connecting a resistance and a capacitance in series is placed in parallel to the negative differential resistance element. In the third shunt element, values of the resistance and the capacitance are such that an impedance of the element is equal to or slightly lower than an absolute value of a combined negative differential resistance of the plurality of negative differential resistance elements arranged adjacent thereto.

(163) In FIG. **18**, in a region surrounded by a broken line **137'** in plan view, a conductor layer **137** serving as one electrode of the capacitance element included in the third shunt element is placed. Meanwhile, in a region surrounded by a broken line **138'**, a resistor **138** serving as the resistance

element is placed. The conductor layer **137** and the resistor **138** are placed in a layer underlying a wiring layer forming the bias voltage line **130**. The third shunt elements are arranged around the individual antennas. To the metal layer **123** forming a part of each of the antennas, the bias voltage line **130** is connected to supply a bias voltage, and each of the third shunt elements is preferably placed in the vicinity of a connection portion thereof, and may appropriately be placed between the antenna and the antenna. Such placement allows a configuration in which one of the third shunt elements is shared by the two antennas adjacent thereto. As a result, a layout efficiency improves to allow a chip size reduction and, since flexibility of size adjustment of the capacitance and resistance of the shunt element increases, the parasitic oscillation is easily suppressed.

(164) As illustrated in a cross-sectional view of FIG. **19**, on the grounded metal layer **124**, a dielectric layer **136** is placed. Note that, since the dielectric layer **136** is used as a dielectric material of the capacitors of the third shunt elements, it is preferable to use a silicon nitride ( $\epsilon=7$ ) having a relatively high dielectric constant for a size reduction of a MIM capacitor structure.

(165) Additionally, on the dielectric layer **136**, the conductor layer **137** is stacked. Thus, in the antenna array **912**, a metal-insulator-metal (MIM) capacitor structure in which the grounded metal layer **124**, the dielectric layer **136**, and the conductor layer **137** are stacked in this order is formed, which corresponds to the capacitance element of each of the third shunt elements. This capacitance element is placed in a layer underlying the bias voltage line **130** placed between the antenna and the antenna. The conductor layer **137** is placed in a layer between the bias voltage line **130** and the grounded metal layer **124**. To the conductor layer **137**, the resistor **138** is connected, and the resistor **138** is connected to the bias voltage line **130**. This resistor **138** corresponds to the resistance element of each of the third shunt elements.

(166) Thus, in the present embodiment, the grounded metal layer **124** and the bias voltage line **130** are electrically connected via the capacitance element and the resistance element each included in the third shunt element. A plurality of the third shunt elements are arranged in an array antenna in such a manner as to be connected to the bias voltage line **130** at respective portions between the antenna and the antenna. In the present embodiment, the third shunt elements are connected to the grounded metal layer **124**, but need only to be connected to a conductive layer at a fixed potential, and may also be connected to another conductive layer.

(167) Note that a configuration in which the third shunt elements are placed at nodes of a high-frequency electric field at the oscillation frequency  $f_{\text{THz}}$  which is standing in the antennas is a configuration having a high impedance at the frequency  $f_{\text{THz}}$  and more appropriate to selectively oscillate only the high frequency at the frequency  $f_{\text{THz}}$ . However, there is a risk that, as a result of an increased number of arrays and sharing of the bias voltage line in the antenna array, unexpected low-frequency multi-mode oscillation occurs. Accordingly, in the present embodiment, the bias voltage line **130** in the array antenna is configured to be set to an impedance lower than that of the negative resistance element in a frequency band lower than the oscillation frequency  $f_{\text{THz}}$ . This can suppress oscillation in another mode even when the number of the arrays in the antenna array increases and allow stable single-frequency oscillation in a terahertz band to be obtained. In the third shunt element, particularly at 10 GHz or higher, parasitic oscillation in a frequency band less than the frequency  $f_{\text{THz}}$  can effectively be suppressed.

(168) FIG. **20** is a top view of an antenna array **1012** as a modification of the antenna array **912** illustrated in FIG. **18**, and FIG. **21** is a cross-sectional view along a line D-D' in FIG. **20**. For the same components as those in FIGS. **18** and **19**, the same reference signs are used, and a description thereof is omitted. The antenna array **1012** is different from the antenna array **912** illustrated in FIGS. **18** and **19** in that each of the resistance elements included in the third shunt elements includes a resistor **138a** and a resistor **138b**.

(169) As illustrated in FIG. **20**, in the antenna array **1012**, the resistor **138a** and the resistor **138b** are arranged between an antenna **1112** and an antenna **1113**. These two resistors **138a** and **138b** correspond to the resistance elements of each of the third shunt elements, and are connected in

parallel to be connected in series to the capacitance element. The resistance elements **138a** and **138b** are arranged in the vicinities of connection portions between the antennas **1112** and **1113** and the bias voltage line **130**, and are arranged in a space resulting from patterning and removal of the wiring layer forming the bias voltage line **130**.

(170) As illustrated in a cross-sectional view of FIG. **21**, each of the resistor **138a** and the resistor **138b** is placed at the same height as that of the bias voltage line **130**. One end portions of the resistor **138a** and the resistor **138b** are connected to the bias voltage line **130**, while other end portions thereof are connected to the conductor layer **137** by using the same wiring layer as that of the bias voltage line **130**.

(171) The third shunt element placed in a region **137''** which is not interposed between an antenna **1111** at an end portion of the antenna array **1012** and another antenna may also be configured such that, as the resistance element, either one (**138a** in the figure) of the resistor **138a** and the resistor **138b** is placed.

(172) A configuration of the antenna array **1012** illustrated in FIGS. **20** and **21** needs only to be such that, at positions at which the resistor **138a** and the resistor **138b** are placed, the wiring layer forming the bias voltage line **130** is removed by patterning, and a material forming the resistors is formed in the resulting space. As a result, fabrication becomes easier than that of a conventional antenna array, and occurrence of a defect can also be suppressed.

(173) Using FIG. **22**, an additional description will be given herein of the first shunt elements, the second shunt elements, and the third shunt elements. FIG. **22** illustrates an example of the configuration in which the pads are arranged along the two facing sides of the chip described in the fourth embodiment, and the pad and the pad are connected with a plurality of bonding wires. Note that, in the following description, the same components as the components described in the fourth embodiment are denoted by the same reference signs, and a detailed description thereof is omitted.

(174) Each of the first shunt elements includes the resistance element **531** and the capacitance element **532**, and is placed around the antenna array **52** in the chip **51**. As the capacitance element **532**, a MIM capacitor is appropriate.

(175) Each of the second shunt elements includes the resistance element **551** and the capacitance element **552**, and is placed on the substrate **50** on which the chip **51** is to be mounted. As the resistance element **551** and the capacitance element **552**, surface mount components (SMD) are used appropriately and, as the capacitance element **552**, e.g., a ceramic capacitor is used.

(176) Each of the third shunt elements includes a resistance element (not shown) and the capacitance element **541**, and is placed in the chip **51** similarly to the first shunt elements to be placed in the antenna array **52**. As the capacitance element **541**, a MIM capacitor is appropriate.

(177) Areas of the respective capacitance elements included in the three shunt elements or magnitudes of capacitance values thereof are preferably set larger in order of the third shunt element, the first shunt element, and the second shunt element (Capacitance Element **541**<Capacitance Element **532**<Capacitance Element **552**). An appropriate arrangement can be made as long as the capacitance value of the capacitance element **541** is at least 1 pF and less than 100 pF, the capacitance value of the capacitance element **532** is at least 100 pF and less than 10 nF, and the capacitance value of the capacitance element **552** is at least 10 nF and less than 100 g. An appropriate arrangement can also be made as long as the resistance value of each of the first shunt element, the second shunt element, and the third shunt element is at least 0.01Ω and less than 10Ω.

(178) The number of the third shunt elements is determined according to the number of antennas in the antenna array **2**, and is preferably the number of the first shunt elements or more and the number of the second shunt elements or more. This can suppress parasitic oscillation and improve an output.

(179) In a case where the number of the antennas in the antenna array **2** is small for adjustment of an output to a low level or the like, the number of the third shunt elements may also be set smaller than the number of the first shunt elements and the number of the second shunt elements.

- (180) When the number of the second shunt elements is set to the number of the first shunt element or more, the number of the second shunt elements that are connected in parallel can be increased. As a result, it is possible to reduce the parasitic inductance of the SMDs, and thereby suppress parasitic oscillation. In addition, as a result of a reduction in the number of the first shunt elements, it is possible to reduce a chip area, which contributes to a reduction in the cost of the antenna array.
- (181) When the number of the second shunt elements is smaller than the number of the first shunt elements, the number of the SMDs included in the second shunt elements can be reduced. Since an area required to mount the SMDs on the substrate is relatively large, a reduction in the number of the SMDs allows a substrate size to be reduced, which contributes to a reduction in the cost of the antenna array.
- (182) As resistors forming the resistance elements of the first shunt elements and the third shunt elements in the chip, Ta, Ti, Mo, Mn, Al, Ni, Nb, W, Ru, or the like can be used appropriately. Moreover, as the resistors, an alloy film, an oxide film, a nitride film, a silicide film, or the like thereof (e.g., TiW, TiN, TaN, WN, WSiN, TaSiN, NbN, MoN, MnO, or RuO) can be used appropriately. Furthermore, as the resistors, polysilicon, a diffusion resistance film obtained by doping Si with an impurity, or the like can be used appropriately.
- (183) As a material of the wiring and the conductive layers each used in the chip, a material having a resistivity of not more than  $1 \times 10^{-6} \Omega \cdot \text{m}$  is preferable. Specifically, as the material, a metal or a metal compound such as Ag, Au, Cu, W, Ni, Cr, Ti, Al, an AuIn alloy, or TiN is used appropriately.
- (184) The dielectric layer included in the MIM capacitor is required to have an insulating property (property of behaving as an insulator/high resistor that does not conduct electricity against a dc voltage), a barrier property (property of preventing diffusion of a metal material used for an electrode), and a workability (property that allows working with submicron precision). As a specific example of a material satisfying the requirement, an inorganic insulator material such as a silicon dioxide ( $\epsilon=4$ ), a silicon nitride ( $\epsilon=7$ ), an aluminum oxide, or an aluminum nitride is used appropriately.
- (185) The negative resistance element includes an electrode and a semiconductor layer and, when the electrode is a conductor ohmic-connected to the semiconductor layer, the electrode is appropriate for reducing an ohmic loss or a RC delay resulting from a series resistance. In a case of using the electrode as an ohmic electrode, as a material thereof, e.g., Ti/Pd/Au, Ti/Pt/Au, AuGe/Ni/Au, TiW, Mo, ErAs, or the like is used appropriately.
- Seventh Embodiment**
- (186) Using FIG. 23, a description will be given of a detection system according to the present embodiment. The detection system may also be a system capable of photographing an image which is, e.g., a camera system. In the present embodiment, by way of example, the camera system will be described. FIG. 23 is a schematic diagram for illustrating a configuration of a camera system **2300** using a terahertz wave.
- (187) The camera system **2300** has an oscillation device **2301**, a detection device **2302**, and a processing unit **2303**. To the oscillation device **2301**, the antenna device described in each of the embodiments can be applied. The detection device **2302** can detect an electromagnetic wave transmitted from the antenna device, and may also be an antenna device using another semiconductor element such as, e.g., a Schottky barrier diode. The terahertz wave emitted from the oscillation device **2301** is reflected by a subject **2305** and detected by the detection device **2302**. The processing unit **2303** processes a signal detected by the detection device **2302**. Image data generated by the processing unit **2303** is output from the output unit **2304**. Such a configuration allows a terahertz image to be acquired.
- (188) In the oscillation device **2301** and the detection device **2302**, optical units may also be provided. Each of the optical units includes at least one material transparent to the terahertz wave such as polyethylene, Teflon (registered trademark), high-resistance silicon, or a polyolefin resin,

and may also include a plurality of layers.

(189) The camera system described in the present embodiment is only exemplary, and may also be in another form. In particular, information to be acquired by the system is not limited to the image information, and a detection system that performs signal detection may also be used.

(190) Each of the embodiments only shows a specific example in implementing the present invention and, due to these, a technical scope of the present invention should not be construed limitative. In other words, the present invention can be implemented in various forms without departing from the technical scope or main features thereof.

(191) With the technology of the present disclosure, it is possible to provide an antenna device and a camera system which excellently operate due to an optimized configuration of a shunt element and suppressed parasitic oscillation.

(192) While the present invention has been described with reference to exemplary embodiments, it is to be understood that the invention is not limited to the disclosed exemplary embodiments. The scope of the following claims is to be accorded the broadest interpretation so as to encompass all such modifications and equivalent structures and functions.

## Claims

1. An antenna device transmitting or receiving an electromagnetic wave, the antenna device comprising: an antenna array in which a plurality of antennas each including a negative differential resistance element and a resonance circuit are arranged; a voltage bias circuit which applies a voltage to the antenna array; a first shunt element which is connected between the antenna array and the voltage bias circuit in parallel relation to each of the negative differential resistance element and the voltage bias circuit, and in which a first resistor and a first capacitor of the first shunt element are connected in series; and a second shunt element which is connected between the first shunt element and the voltage bias circuit in parallel relation to each of the negative differential resistance element and the voltage bias circuit, and in which a second resistor and a second capacitor of the second shunt element are connected in series, wherein each of the first shunt element and the second shunt element has a low impedance with respect to a resistance value of the negative differential resistance element used as a reference.

2. The antenna device according to claim 1, wherein expressions (1) to (3) below are satisfied:

$$R_p + 1/(2\pi \times f \times C_p) < r \quad (1)$$

$$R_c + 1/(2\pi \times f \times C_c) < r \quad (2)$$

$L/(C_c \times r) < R_c \quad (3)$  where  $r$  is an absolute value of the resistance value of the negative differential resistance element,  $R_p$  is a resistance value of the second resistor,  $C_p$  is a capacitance value of the second capacitor,  $R_c$  is a resistance value of the first resistor,  $C_c$  is a capacitance value of the first capacitor,  $L$  is an inductance of a path connecting the first shunt element and the second shunt element, and  $f$  is a frequency less than a resonance frequency of the resonance circuit.

3. The antenna device according to claim 1, wherein the inductance  $L$  of the path connecting the first shunt element and the second shunt element satisfies an expression (4) below:

$L \leq 5 \text{ nH} \quad (4)$  wherein, in a case where the path is divided into a first portion in which a cross section of the path can be approximated to a circular shape and a second portion in which the cross section of the path can be approximated to a quadrilateral shape, an inductance  $L_1$  of the first portion is calculated according to an expression (5) below, while an inductance  $L_2$  of the second portion is calculated according to an expression (6) below:

$$L_1 = 0.2 \times l_1 \times [\ln(4 \times l_1 / d) - 0.75] \quad (5)$$

$L_2 = 0.2 \times l_2 \times [\ln\{2 \times l_2 / (w + h)\} + 0.2235] \times (w + h) / l_2 + 0.5 \quad (6)$  where  $l_1$  is a length of the first portion,  $d$  is a diameter of a cross section of the first portion,  $l_2$  is a length of the second portion,  $w$  is a width of the second portion, and  $h$  is a thickness of the second portion.

4. The antenna device according to claim 1, wherein a plurality of pairs of the first shunt elements

and the second shunt elements are arranged, and wherein at least two of the pairs of the first shunt elements and the second shunt elements are placed at positions symmetrical to each other with respect to an axis passing through a center of the antenna array.

5. The antenna device according to claim 4, wherein the two pairs of the first shunt elements and the second shunt elements are arranged such that the antenna array is interposed between the two pairs of the first shunt elements and the second shunt elements.

6. The antenna device according to claim 4, wherein the first shunt elements are arranged on a chip on which the antenna array is to be placed, wherein the chip is a chip having a quadrilateral shape, and wherein the second shunt elements included in the respective pairs of the first shunt elements and the second shunt elements are arranged in the vicinities of corners of the chip.

7. The antenna device according to claim 4, wherein the second shunt elements included in the two respective pairs of the first shunt elements and the second shunt elements are connected in parallel.

8. The antenna device according to claim 1, wherein the first shunt element is placed on the chip on which the antenna array is to be placed, and wherein the second shunt element is placed on a substrate on which the chip is to be placed.

9. The antenna device according to claim 8, wherein the path connecting the first shunt element and the second shunt element includes a first pad placed on the chip and a second pad placed on the substrate, and wherein a bias voltage is supplied to the antenna array via each of the first pad and the second pad.

10. The antenna device according to claim 9, further comprising: a third pad placed on the chip and a fourth pad placed on the substrate, wherein a ground voltage is supplied to the antenna array via each of the third pad and the fourth pad, wherein the chip is a chip having a quadrilateral shape, wherein the bias voltage is supplied from a side of the chip, on which a first side thereof is present, to the antenna array via each of the first pad and the second pad, and wherein the ground voltage is supplied from a side of the chip, on which a second side thereof different from the first side is present, to the antenna array via each of the third pad and the fourth pad.

11. The antenna device according to claim 9, wherein the first pad and the second pad are connected using a plurality of bonding wires connected in parallel.

12. The antenna device according to claim 8, wherein the second resistor is wiring placed in the substrate.

13. The antenna device according to claim 1, wherein a combined resistance value of the negative differential resistance elements in the antenna array is not more than  $1\ \Omega$ .

14. The antenna device according to claim 1, wherein a length of the path connecting the first shunt element and the second shunt element is not more than 4 mm.

15. The antenna device according to claim 14, wherein the length of the path connecting the first shunt element and the second shunt element is not more than 2 mm.

16. The antenna device according to claim 1, wherein a frequency band of the electromagnetic wave includes at least a part of a frequency band of at least 30 GHz and not more than 30 THz.

17. The antenna device according to claim 1, wherein the negative differential resistance element is a resonant tunneling diode.

18. The antenna device according to claim 1, wherein the first capacitor is a MIM (Metal-Insulator-Metal) capacitor.

19. The antenna device according to claim 1, further comprising: a third shunt element connected in parallel to the negative differential resistance element in the antenna array and including at least a third capacitor.

20. The antenna device according to claim 19, wherein a plurality of the third shunt elements are arranged between the antenna and the antenna.

21. The antenna device according to claim 20, wherein each of the third shunt elements is shared between the two antennas each adjacent to the third shunt element.

22. The antenna device according to claim 19, wherein respective areas or capacitance values of the

third capacitor, the first capacitor, and the second capacitor are progressively larger in this order.

23. The antenna device according to claim 19, wherein the number of the third shunt elements is the number of the first shunt elements or more and the number of the second shunt elements or more.

24. The antenna device according to claim 19, wherein the number of the third shunt elements is less than the number of the first shunt elements and less than the number of the second shunt elements.

25. The antenna device according to claim 1, wherein the number of the second shunt elements is the number of the first shunt elements or more.

26. The antenna device according to claim 1, wherein the number of the second shunt elements is less than the number of the first shunt elements.

27. An antenna device transmitting or receiving an electromagnetic wave, the antenna device comprising: a chip having an antenna array in which a plurality of antennas each including a negative differential resistance element and a resonance circuit are arranged; a substrate on which the chip is to be placed; and a voltage bias circuit that applies a voltage to the antenna array, wherein the chip has: a first shunt element connected in parallel to each of the negative differential resistance element and the voltage bias circuit and including at least a first capacitor; and a plurality of pads including at least each of a first pad and a second pad to supply a predetermined voltage to the antenna array, the substrate has: a second shunt element connected in parallel to each of the negative differential resistance element and the voltage bias circuit, and including at least a second capacitor, and moreover placed in the substrate, and wherein the antenna array is located between the first pad and the second pad.

28. The antenna device according to claim 27, further comprising: a third shunt element connected in parallel to the negative differential resistance element in the antenna array and including at least a third capacitor.

29. A camera system comprising: the antenna device according to claim 1; a detection device for detecting the electromagnetic wave transmitted from the antenna device; and a processing unit that processes a signal from the detection device.

30. A camera system comprising: the antenna device according to claim 27; a detection device for detecting the electromagnetic wave transmitted from the antenna device; and a processing unit that processes a signal from the detection device.

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